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VAPOR CHAMBER, ELECTRONIC DEVICE, METALLIC SHEET FOR VAPOR CHAMBER AND MANUFACTURING METHOD OF VAPOR CHAMBER

Abstract

A liquid flow path portion of a vapor chamber according to this invention includes a first main flow groove, a second main flow groove and a third main flow groove. A first convex array including a plurality of first convex portions arranged via a first communicating groove is provided between the first main flow groove and the second main flow groove. A second convex array including a plurality of second convex portions arranged via a second communicating groove is provided between the second main flow groove and the third main flow groove. The main flow groove includes a first intersection at which at least a part of the first communicating groove faces each second convex portion and a second intersection at which at least a part of the second communicating groove faces each first convex portion.

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Background/Summary

CROSS REFERENCE TO RELATED APPLICATION [0001] This application is a continuation of U.S. application Ser. No. 18/223,723, filed Jul. 19, 2023, which is a continuation of U.S. application Ser. No. 17/554,848, filed Dec. 17, 2021, which is a continuation of U.S. application Ser. No. 16/488,843, filed Aug. 26, 2019, which is the national phase of PCT/JP2018/006758, filed Feb. 23, 2018, which claims priority to Japanese Patent Application 2017-217633, filed Nov. 10, 2017, Japanese Patent Application 2017-217593, filed Nov. 10, 2017, and Japanese Patent Application 2017-033622, filed Feb. 25, 2017, the contents of each of which are incorporated herein by reference.

TECHNICAL FIELD

[0002] The present invention relates to a vapor chamber including a sealed space in which a working fluid is enclosed, an electronic device, a metallic sheet for the vapor chamber and a manufacturing method of the vapor chamber.

BACKGROUND ART

[0003] A device accompanied with heat generation such as a central processing unit (CPU), a light-emitting diode (LED) and a power semiconductor, which is used in a mobile terminal and the like including a portable terminal or a tablet terminal, is cooled by a heat release member such as a heat pipe (for example, see Patent Literatures 1 to 5.) In recent years, to make a mobile terminal etc. thinner, thickness reduction of the heat release member has been requested, and development has been advanced for a vapor chamber which can be thinner than the heat pipe. In the vapor chamber, a working fluid is enclosed, and the working fluid absorbs heat in the device and releases the heat to the outside, whereby the device is cooled.

[0004] More specifically, the working fluid in the vapor chamber evaporates to turn into a vapor by receiving heat from the device at a portion close to the device (an evaporating portion.) After that, the vapor moves to a position away from the evaporating portion, and is cooled and liquidized by condensation. In the vapor chamber, a liquid flow path portion as a capillary structure (wick) is provided, and the working fluid in liquid form is transported toward the evaporating portion by

passing through the liquid flow path portion, and at the evaporating portion, receives the heat again to evaporate. In this way, the working fluid transfers the heat of the device by circulating in the vapor chamber while executing a change of phase, that is, repeating evaporation and condensation, which improves heat release efficiency.

[0005] Incidentally, the liquid flow path portion includes a plurality of grooves extending in a first direction. The working fluid obtains thrust toward the evaporating portion by receiving capillary action, and passes through the grooves toward the evaporating portion. Also, to reciprocate the working fluid in the grooves adjacent to each other, another groove extending in a second direction orthogonal the first direction is provided. In this way, in the liquid flow path portion, a plurality of grooves are formed to be lattice-shaped, whereby the working fluid is evenly distributed in the liquid flow path portion.

Patent Literature 1

[0006] Japanese Patent Laid-Open No. 2015-59693

Patent Literature 2

[0007] Japanese Patent Laid-Open No. 2015-88882

Patent Literature 3

[0008] Japanese Patent Laid-Open No. 2016-17702

Patent Literature 4

[0009] Japanese Patent Laid-Open No. 2016-50682

Patent Literature 5

[0010] Japanese Patent Laid-Open No. 2016-205693

DISCLOSURE OF THE INVENTION

[0011] However, when a plurality of grooves are formed in a lattice shape, a problem can occur due to a pressure received from the outside air.

[0012] That is, the vapor chamber is constituted by two metallic sheets, and the above-described grooves are formed on at least one metallic sheet. Thereby, in a portion where the grooves are formed in the metallic sheet, a thickness of a metal material becomes small. Since a space in the liquid flow path portion is depressurized, the metallic sheet receives a pressure in a direction of being recessed inwardly from outside air. Consequently, the metallic sheet has a risk of being recessed inwardly along the grooves. In particular, when thickness reduction of the vapor chamber is requested as described above, the thickness of metallic sheets become smaller, and recess can be easily generated.

[0013] At an intersection at which the grooves orthogonal to each other intersect, when the metallic sheet is recessed along the grooves extending in the second direction, the corresponding recess traversing the grooves along the first direction can be formed. In such a case, a cross-sectional area of a flow path of the grooves along the first direction is reduced, which can increase flow path resistance of the working fluid. This reduces a transport function of the working fluid in liquid form toward the evaporating portion, and the supply amount of the working fluid to the evaporating portion can be reduced. In such a case, such a problem occurs that the amount of heat transport from the evaporating portion is reduced, and thermal transport efficiency is lowered.

[0014] The present invention is made considering this point, and an object of the present invention is to provide a vapor chamber which secures the cross-sectional area of the flow path of the liquid flow path portion to improve the transport function of the working fluid in liquid form and improves the thermal transport efficiency, an electronic device, a metallic sheet for the vapor chamber and a manufacturing method of the vapor chamber.

[0015] This invention provides a vapor chamber in which a working fluid is enclosed, the vapor chamber including: [0016] a first metallic sheet; [0017] a second metallic sheet provided on the first metallic sheet; and [0018] a sealed space which is provided between the first metallic sheet and the second metallic sheet and which includes a vapor flow path portion through which a vapor of the working fluid passes and a liquid flow path portion through which the working fluid in liquid

form passes, [0019] wherein the liquid flow path portion is provided in a surface of the first metallic sheet on a side of the second metallic sheet, [0020] the liquid flow path portion includes a first main flow groove, a second main flow groove and a third main flow groove, each of which extends in a first direction and through which the working fluid in liquid form passes, [0021] the first main flow groove, the second main flow groove and the third main flow groove are arranged in this order in a second direction orthogonal to the first direction, [0022] a first convex array which includes a plurality of first convex portions arranged in the first direction via a first communicating groove is provided between the first main flow groove and the second main flow groove, [0023] a second convex array which includes a plurality of second convex portions arranged in the first direction via a second communicating groove is provided between the second main flow groove and the third main flow groove, [0024] the first communicating groove allows communication between the first main flow groove and the second main flow groove, [0025] the second communicating groove allows communication between the second main flow groove and the third main flow groove, and [0026] the second main flow groove includes a first intersection at which at least a part of the first communicating groove faces each second convex portion and a second intersection at which at least a part of the second communicating groove faces each first convex portion.

[0027] Additionally, in the vapor chamber described above, it is acceptable that the first intersection and the second intersection of the second main flow groove are adjacent to each other.

[0028] Additionally, in the vapor chamber described above, it is acceptable that the second main flow groove includes a plurality of the first intersections and a plurality of the second intersections, and [0029] the first intersections and the second intersections of the second main flow groove are alternately arranged.

[0030] Additionally, in the vapor chamber described above, it is acceptable that the liquid flow path portion further includes a fourth main flow groove which extends in the first direction and through which the working fluid in liquid form passes, [0031] the fourth main flow groove is arranged on an opposite side from the second main flow groove to the third main flow groove, [0032] a third convex array which includes a plurality of third convex portions arranged in the first direction via a third communicating groove is provided between the third main flow groove and the fourth main flow groove, [0033] the third communicating groove allows communication between the third main flow groove and the fourth main flow groove, and [0034] the third main flow groove includes a first intersection at which at least a part of the second communicating groove faces each third convex portion and a second intersection at which at least a part of the third communicating groove faces each second convex portion.

[0035] Additionally, in the vapor chamber described above, it is acceptable that the first intersection and the second intersection of the third main flow groove are adjacent to each other.

[0036] Additionally, in the vapor chamber described above, it is acceptable that the third main flow groove includes a plurality of the first intersections and a plurality of the second intersections, and [0037] the first intersections and the second intersections of the third main flow groove are alternately arranged.

[0038] Additionally, in the vapor chamber described above, it is acceptable that the second metallic sheet includes a planar abutting surface which abuts a surface of the first metallic sheet on a side of the second metallic sheet and covers the second main flow groove.

[0039] Additionally, in the vapor chamber described above, it is acceptable that a width of the second main flow groove is larger than a width of the first convex portions and a width of the second convex portions.

[0040] Additionally, in the vapor chamber described above, it is acceptable that a width of the first communicating groove is larger than a width of the first main flow groove and the width of the second main flow groove, and [0041] a width of the second communicating groove is larger than the width of the second main flow groove and a width of the third main flow groove.

[0042] Additionally, in the vapor chamber described above, it is acceptable that a depth of the first communicating groove is deeper than a depth of the first main flow groove and a depth of the second main flow groove, and [0043] a depth of the second communicating groove is deeper than the depth of the second main flow groove and a depth of the third main flow groove.

[0044] Additionally, in the vapor chamber described above, it is acceptable that a depth of the first intersection and a depth of the second intersection of the second main flow groove are deeper than a depth of a portion between the first convex portions and the second convex portions adjacent to each other in the second main flow groove.

[0045] Additionally, in the vapor chamber described above, it is acceptable that the depth of the first intersection and the depth of the second intersection of the second main flow groove are deeper than the depth of the first communicating groove and the depth of the second communicating groove.

[0046] Additionally, in the vapor chamber described above, it is acceptable that each first convex portion includes a pair of first convex end portions provided at both end portions in the first direction and a first convex intermediate portion provided between the pair of first convex end portions, and [0047] a width of the first convex intermediate portion is smaller than a width of the first convex end portions.

[0048] Additionally, in the vapor chamber described above, it is acceptable that a rounded curved portion is provided at a corner portion of each first convex portion.

[0049] Additionally, in the vapor chamber described above, it is acceptable that the second metallic sheet includes a plurality of main flow groove convex portions, each of which protrudes toward the first main flow groove, the second main flow groove and the third main flow groove of the first metallic sheet from a surface of the second metallic sheet on a side of the first metallic sheet.

[0050] Additionally, in the vapor chamber described above, it is acceptable that a cross section of each main flow groove convex portion is formed to be curved.

[0051] Additionally, in the vapor chamber described above, it is acceptable that the second metallic sheet includes a plurality of communicating groove convex portions, each of which protrudes toward the first communicating groove and the second communicating groove of the first metallic sheet from the surface of the second metallic sheet on a side of the first metallic sheet.

[0052] Additionally, in the vapor chamber described above, it is acceptable that a cross section of each communicating groove convex portion is formed to be curved.

[0053] Also, the present invention provides an electronic device including: [0054] a housing; [0055] a device housed in the housing; and [0056] a vapor chamber as described above, the vapor chamber is thermally contacted to the device.

[0057] Also, the present invention provides a metallic sheet for a vapor chamber used for the vapor chamber including a sealed space which includes a vapor flow path portion in which a working fluid is enclosed and through which a vapor of the working fluid passes and a liquid flow path portion through which the working fluid in liquid form passes, the metallic sheet for a vapor chamber including: [0058] a first surface; and [0059] a second surface provided on an opposite side from the first surface, [0060] wherein the liquid flow path portion is provided to the first surface, [0061] the liquid flow path portion includes a first main flow groove, a second main flow groove and a third main flow groove, each of which extends in a first direction and through which the working fluid in liquid form passes, [0062] the first main flow groove, the second main flow groove and the third main flow groove are arranged in this order in a second direction orthogonal to the first direction, [0063] a first convex array which includes a plurality of first convex portions arranged in the first direction via a first communicating groove is provided between the first main flow groove and the second main flow groove, [0064] a second convex array which includes a plurality of second convex portions arranged in the first direction via a second communicating groove is provided between the second main flow groove and the third main flow groove, [0065] the first communicating groove allows communication between the first main flow groove and the

second main flow groove, [0066] the second communicating groove allows communication between the second main flow groove and the third main flow groove, and [0067] the second main flow groove includes a first intersection at which at least a part of the first communicating groove faces each second convex portion and a second intersection at which at least a part of the second communicating groove faces each first convex portion.

[0068] Also, the present invention provides a manufacturing method of a vapor chamber including a sealed space which is provided between a first metallic sheet and a second metallic sheet and in which a working fluid is enclosed, the sealed space including a vapor flow path portion through which a vapor of the working fluid passes and a liquid flow path portion through which the working fluid in liquid form passes, the manufacturing method for vapor chamber including:

[0069] half-etching in which a surface of the first metallic sheet on a side of the second metallic sheet is half-etched to form the liquid flow path portion; [0070] joining the first metallic sheet and the second metallic sheet such that the sealed space is formed between the first metallic sheet and the second metallic sheet; and [0071] enclosing the working fluid in the sealed space, [0072] wherein the liquid flow path portion includes a first main flow groove, a second main flow groove and a third main flow groove, each of which extends in a first direction and through which the working fluid in liquid form passes, [0073] the first main flow groove, the second main flow groove and the third main flow groove are arranged in this order in a second direction orthogonal to the first direction, [0074] a first convex array which includes a plurality of first convex portions arranged in the first direction via a first communicating groove is provided between the first main flow groove and the second main flow groove, [0075] a second convex array which includes a plurality of second convex portions arranged in the first direction via a second communicating groove is provided between the second main flow groove and the third main flow groove, [0076] the first communicating groove allows communication between the first main flow groove and the second main flow groove, [0077] the second communicating groove allows communication between the second main flow groove and the third main flow groove, and [0078] the second main flow groove includes a first intersection at which at least a part of the first communicating groove faces each second convex portion and a second intersection at which at least a part of the second communicating groove faces each first convex portion.

[0079] According to the present invention, the cross-sectional area of the flow path of the liquid flow path portion is secured and the transport function of the working fluid in liquid form is improved, which improves the thermal transport efficiency.

Description

BRIEF DESCRIPTION OF DRAWINGS

[0080] FIG. 1 is a schematic perspective view for explaining an electronic device according to a first embodiment of the present invention.

[0081] FIG. 2 is a top view showing a vapor chamber according to the first embodiment of the present invention.

[0082] FIG. 3 is a cross-sectional view showing the vapor chamber of FIG. 2 taken along the line A-A.

[0083] FIG. 4 is a top view of a lower metallic sheet of FIG. 2.

[0084] FIG. 5 is a bottom view of an upper metallic sheet of FIG. 2.

[0085] FIG. 6 is an enlarged top view showing a liquid flow path portion of FIG. 4.

[0086] FIG. 7 is a cross-sectional view of FIG. 6 taken along the line B-B with addition of an upper flow path wall portion of the upper metallic sheet.

[0087] FIG. 8 is a drawing for explaining a preparation step of the lower metallic sheet in a manufacturing method of the vapor chamber according to the first embodiment of the present

invention.

[0088] FIG. **9** is a drawing for explaining a first half-etching step of the lower metallic sheet in the manufacturing method of the vapor chamber according to the first embodiment of the present invention.

[0089] FIG. **10** is a drawing for explaining a second half-etching step of the lower metallic sheet in the manufacturing method of the vapor chamber according to the first embodiment of the present invention.

[0090] FIG. **11** is a drawing for explaining a temporary joint step in the manufacturing method of the vapor chamber according to the first embodiment of the present invention.

[0091] FIG. **12** is a drawing for explaining a permanent joint step in the manufacturing method of the vapor chamber according to the first embodiment of the present invention.

[0092] FIG. **13** is a drawing for explaining a enclosing step of a working fluid in the manufacturing method of the vapor chamber according to the first embodiment of the present invention.

[0093] FIG. **14** is a drawing showing a modification of FIG. **6**.

[0094] FIG. **15** is a top view showing a modification of a liquid flow path convex portion shown in FIG. **6**.

[0095] FIG. **16** is a top view showing another modification of the liquid flow path convex portion shown in FIG. **6**.

[0096] FIG. **17** is a drawing showing another modification of FIG. **6**.

[0097] FIG. **18** is a drawing showing another modification of FIG. **3**.

[0098] FIG. **19** is an enlarged top view showing a liquid flow path portion a vapor chamber according to a second embodiment of the present invention.

[0099] FIG. **20** is a cross-sectional view of FIG. **19** taken along the line C-C with addition of an upper flow path wall portion of the upper metallic sheet.

[0100] FIG. **21** is a cross-sectional view of FIG. **19** taken along the line D-D with addition of the upper flow path wall portion of the upper metallic sheet.

[0101] FIG. **22** is a cross-sectional view of FIG. **19** taken along the line E-E with addition of the upper flow path wall portion of the upper metallic sheet.

[0102] FIG. **23** is an enlarged cross-sectional view showing a main flow groove convex portion in a vapor chamber according to a third embodiment of the present invention, corresponding to FIG. **20**.

[0103] FIG. **24** is an enlarged cross-sectional view showing a communicating groove convex portion in the vapor chamber according to the third embodiment of the present invention, corresponding to FIG. **21**.

[0104] FIG. **25** is an enlarged cross-sectional view showing a communicating groove convex portion in the vapor chamber according to the third embodiment of the present invention, corresponding to FIG. **22**.

DESCRIPTION OF EMBODIMENTS

[0105] Hereinafter, embodiments according to the present invention will be explained with reference to drawings. Additionally, for convenience of illustration and easy understanding, in the drawings attached to the present specification, the scale and an aspect ratio etc. are appropriately changed and exaggerated from those of a real product.

First Embodiment

[0106] A vapor chamber, an electronic device, a metallic sheet for the vapor chamber and a manufacturing method of the vapor chamber according to a first embodiment of the present invention will be explained using FIGS. **1** to **18**. A vapor chamber **1** according to this embodiment is an apparatus mounted on an electronic device E for cooling a device D as a heating element housed in the electronic device E. As an example of the device D, an electronic device accompanied with heat generation (a device to be cooled) such as a central processing unit (CPU), a light-emitting diode (LED) and a power transistor, which is used in a mobile terminal and the like such as a portable terminal or a tablet terminal, can be listed.

[0107] Here, firstly, an explanation will be made on the electronic device E on which the vapor chamber **1** is mounted according to this embodiment taking a tablet terminal as an example. As shown in FIG. **1**, the electronic device E (tablet terminal) includes a housing H, the device D housed in the housing H and the vapor chamber **1**. In the electronic device E shown in FIG. **1**, a touch panel display TD is provided in a front surface of the housing H. The vapor chamber **1** is housed in the housing H and arranged to thermally contact to the device D. Thereby, heat generated at the device D when the electronic device E is used can be received by the vapor chamber **1**. The heat received by the vapor chamber **1** is released to the outside of the vapor chamber **1** via a working fluid **2** which will be described later. In this way, the device D is effectively cooled. If the electronic device E is the tablet terminal, the device D corresponds to the central processing unit etc.

[0108] Next, the vapor chamber **1** according to this embodiment will be explained. The vapor chamber **1** includes a sealed space **3** in which the working fluid **2** is enclosed, and the working fluid **2** in the sealed space **3** repeats change of phase, so that the device D of the electronic device E described above is effectively cooled.

[0109] The vapor chamber **1** is formed as a schematically thin plate. While the vapor chamber **1** may have any planar shape, a rectangle as shown in FIG. **2** may be applied. In this case, the vapor chamber **1** includes four linear outer edges **1a**, **1b** forming a planar outline. Among these, two outer edges **1a** are formed along a first direction X which will be described later, and remained two outer edges **1b** are formed along a second direction Y which will be described later. For example, a planar shape of the vapor chamber **1** may be a rectangle having one side of 1 cm and the other side of 3 cm, or may be a square having one side of 15 cm. The vapor chamber **1** may have any planar dimension.

[0110] As shown in FIGS. **2** and **3**, the vapor chamber **1** includes a lower metallic sheet **10** (first metallic sheet) having an upper surface **10a** (first surface) and a lower surface **10b** (second surface) provided on an opposite side from the upper surface **10a**, and an upper metallic sheet **20** (second metallic sheet) provided on the lower metallic sheet **10**. The lower metallic sheet **10** and the upper metallic sheet **20** both correspond to a metallic sheet for a vapor chamber. The upper metallic sheet **20** includes a lower surface **20a** (a surface on a side of the lower metallic sheet **10**) layered on the upper surface **10a** of the lower metallic sheet **10** (a surface on a side of the upper metallic sheet **20**) and an upper surface **20b** provided on an opposite side from the lower surface **20a**. The device D which is an object of cooling is attached to the lower surface **10b** of the lower metallic sheet **10** (especially, a lower surface of an evaporating portion **11** which will be described later.)

[0111] The thickness of the vapor chamber **1** is, for example, 0.1 mm to 1.0 mm. While FIG. **3** shows a case where a thickness T1 of the lower metallic sheet **10** and a thickness T2 of the upper metallic sheet **20** are equal, not limited to this, the thickness T1 of the lower metallic sheet **10** and the thickness T2 of the upper metallic sheet **20** may be different.

[0112] The sealed space **3** in which the working fluid **2** is enclosed is formed between the lower metallic sheet **10** and the upper metallic sheet **20**. In this embodiment, the sealed space **3** includes a vapor flow path portion through which a vapor of the working fluid **2** mainly passes (a lower vapor flow path recess **12** and an upper vapor flow path recess **21** which will be described later) and a liquid flow path portion **30** through which the working fluid **2** in liquid form mainly passes. As examples of the working fluid **2**, pure water, ethanol, methanol and acetone etc. can be listed.

[0113] The lower metallic sheet **10** and the upper metallic sheet **20** are joined by diffused junction which will be described later. In the embodiment shown in FIGS. **2** and **3**, an example in which the lower metallic sheet **10** and the upper metallic sheet **20** are formed to be rectangular in a planar view is shown. However, this is not restrictive. Here, the planar view is a state seen in a direction which is orthogonal to a surface at which the vapor chamber **1** receives heat from the device D (the lower surface **10b** of the lower metallic sheet **10**) as well as a surface at which the received heat is released (the upper surface **20b** of the upper metallic sheet **20**), and for example, this corresponds

to a state that the vapor chamber **1** is seen from an upper side (see FIG. 2) or seen from a lower side.

[0114] Additionally, when the vapor chamber **1** is installed in the mobile terminal, depending on an attitude of the mobile terminal, the vertical relationship between the lower metallic sheet **10** and the upper metallic sheet **20** may be changed. However, in this embodiment, for convenience, a metallic sheet which receives heat from the device **D** is called as the lower metallic sheet **10**, while a metallic sheet which releases the received heat is called as the upper metallic sheet **20**, and an explanation will be made in a state that the lower metallic sheet **10** is disposed at the lower side and the upper metallic sheet **20** is disposed at the upper side.

[0115] As shown in FIG. 4, the lower metallic sheet **10** includes the evaporating portion **11** in which the working fluid **2** evaporates to generate a vapor, and the lower vapor flow path recess **12** (a first vapor flow path recess) provided in the upper surface **10a** and formed to be rectangular in a planar view. In these components, the lower vapor flow path recess **12** constitutes a part of the sealed space **3** described above, and is mainly configured such that the vapor generated in the evaporating portion **11** passes.

[0116] The evaporating portion **11** is disposed in the lower vapor flow path recess **12**. The vapor in the lower vapor flow path recess **12** is diffused in a direction away from the evaporating portion **11**, and most of the vapor is transported to a peripheral portion with a relatively low temperature. Additionally, the evaporating portion **11** is a portion at which the working fluid **2** in the sealed space **3** evaporates by receiving heat from the device **D** attached to the lower surface **10b** of the lower metallic sheet **10**. Consequently, the term of the evaporating portion **11** is not a concept limited to a portion overlapped with the device **D**, and is used as a concept including a portion which is not overlapped with the device **D** but allows the working fluid **2** to evaporate. Here, the evaporating portion **11** can be provided at any portion of the lower metallic sheet **10**. However, in FIGS. 2 and 4, an example in which the evaporating portion **11** is provided at a center portion of the lower metallic sheet **10** is shown. In this case, an operation of the vapor chamber **1** can be stabilized regardless of the attitude of the mobile terminal in which the vapor chamber **1** is installed.

[0117] As shown in FIGS. 3 and 4, in this embodiment, a plurality of lower flow path wall portions **13** (a first flow path wall portion) protruding upward from a bottom surface **12a** (which will be described later) of the lower vapor flow path recess **12** (a direction orthogonal to the bottom surface **12a**) are provided in the lower vapor flow path recess **12** of the lower metallic sheet **10**. In this embodiment, an example in which the lower flow path wall portions **13** extend to be elongated along the first direction **X** of the vapor chamber **1** (a longitudinal direction, a right and left direction in FIG. 4) is shown. Each lower flow path wall portion **13** includes an upper surface **13a** (a first abutting surface, a protruding end surface) abutting a lower surface **22a** of the corresponding upper flow path wall portion **22** which will be described later. The upper surface **13a** is a surface which is not etched by two etching steps which will be described later, and formed on the same plane as the upper surface **10a** of the lower metallic sheet **10**. Also, each lower flow path wall portion **13** is separated from each other with even intervals, and disposed to be parallel with each other. In this way, such a configuration is made that the vapor of the working fluid **2** flows along a periphery of each lower flow path wall portion **13** and the vapor is transported to a peripheral portion of the lower vapor flow path recess **12**, which inhibits blocking of vapor flow. Also, each lower flow path wall portion **13** is disposed to be overlapped with the corresponding upper flow path wall portion **22** (which will be described later) of the upper metallic sheet **20** in a planar view, which improves mechanical strength of the vapor chamber **1**. A width **w0** of each lower flow path wall portion **13** is 0.1 mm to 30 mm for example, preferably 0.1 mm to 2.0 mm, and the interval **d** between the lower flow path wall portions **13** adjacent to each other is 0.1 mm to 30 mm, preferably 0.1 mm to 2.0 mm. Here, the width **w0** means the dimension of each lower flow path wall portion **13** in the second direction **Y** orthogonal to the first direction **X** of each lower flow path wall portion **13**, and

for example, corresponds to a vertical direction in FIG. 4. Also, a height h_0 of each lower flow path wall portion **13** (in other words, a depth of the lower vapor flow path recess **12**) (see FIG. 3) is preferably smaller than a thickness T_1 of the lower metallic sheet **10** which will be described later by 10 μm or more. In this case, the difference between the thickness T_1 and the height h_0 , that is, the thickness of the metal material of the lower metallic sheet **10** at a portion where the lower vapor flow path recess **12** is formed can be 10 μm or more. Thereby, the strength of the corresponding portion can be secured, which prevents deformation to be recessed inwardly to a pressure received from the outside air. Such height h_0 may be 10 μm to 300 μm . For example, when a thickness T_0 of the vapor chamber **1** is 0.5 mm and the thickness T_1 of the lower metallic sheet **10** and a thickness T_2 of the upper metallic sheet **20** are equal, the height h_0 can be 200 μm .

[0118] As shown in FIGS. 3 and 4, a lower peripheral wall **14** is provided at a peripheral portion of the lower metallic sheet **10**. The lower peripheral wall **14** is formed to surround the sealed space **3**, especially the lower vapor flow path recess **12** to define the sealed space **3**. Also, lower alignment holes **15** which execute positioning between the lower metallic sheet **10** and the upper metallic sheet **20** are respectively provided at four corners of the lower peripheral wall **14** in a planar view. [0119] In this embodiment, the upper metallic sheet **20** has substantially the same configuration as in the lower metallic sheet **10** excluding the point that the liquid flow path portion **30** which will be described later is not provided. Hereinafter, the configuration of the upper metallic sheet **20** will be explained in more detail.

[0120] As shown in FIGS. 3 and 5, the upper metallic sheet **20** includes an upper vapor flow path recess **21** (a second vapor flow path recess) provided in the lower surface **20a**. The upper vapor flow path recess **21** constitutes a part of the sealed space **3**, and is mainly configured to diffuse the vapor generated in the evaporating portion **11** for cooling. More concretely, the vapor in the upper vapor flow path recess **21** is diffused in a direction away from the evaporating portion **11**, and most of the vapor is transported to the peripheral portion with a relatively low temperature. Also, as shown in FIG. 3, a housing member H_a constituting a part of the housing **H** such as the mobile terminal (see FIG. 1) is disposed on the upper surface **20b** of the upper metallic sheet **20**. Thereby, the vapor in the upper vapor flow path recess **21** is cooled by the outside via the upper metallic sheet **20** and the housing member H_a .

[0121] As shown in FIGS. 2, 3 and 5, in this embodiment, a plurality of upper flow path wall portions **22** (a second flow path wall portion) protruding from the bottom surface **21a** of the upper vapor flow path recess **21** to a lower side (a direction perpendicular to the bottom surface **21a**) are provided in the upper vapor flow path recess **21** of the upper metallic sheet **20**. In this embodiment, an example in which the upper flow path wall portions **22** extend to be elongated along the first direction X (a right and left direction of FIG. 5) of the vapor chamber **1** is shown. Each upper flow path wall portion **22** includes the planar lower surface **22a** (a second abutting surface, a protruding end surface) which abuts the upper surface **10a** of the lower metallic sheet **10** (more specifically, the upper surface **13a** of each lower flow path wall portion **13** described above) and covers the liquid flow path portion **30**. Also, each upper flow path wall portion **22** is separated from each other with even intervals and disposed to be parallel with each other. In this way, such a configuration is made that the vapor of the working fluid **2** flows along a periphery of each upper flow path wall portion **22** and the vapor is transported to a peripheral portion of the upper vapor flow path recess **21**, which inhibits blocking of vapor flow. Also, each upper flow path wall portion **22** is disposed to be overlapped with the corresponding lower flow path wall portion **13** of the lower metallic sheet **10** in a planar view, which improves mechanical strength of the vapor chamber **1**. Additionally, a width and a height of each upper flow path wall portion **22** are preferably the same as the width w_0 and the height h_0 of each lower flow path wall portion **13** described above. Here, while the bottom surface **21a** of the upper vapor flow path recess **21** can be also said as a ceiling surface in the vertical disposition relationship between the lower metallic sheet **10** and the upper metallic sheet **20** as shown in FIG. 3 etc., this corresponds to a surface on a deeper side of the upper vapor flow path

recess **21**, so that this is described as the bottom surface **21a** in the present specification.

[0122] As shown in FIGS. **3** and **5**, an upper peripheral wall **23** is provided at a peripheral portion of the upper metallic sheet **20**. The upper peripheral wall **23** is formed to surround the sealed space **3**, especially the upper vapor flow path recess **21** to define the sealed space **3**. Also, upper alignment holes **24** which execute positioning between the lower metallic sheet **10** and the upper metallic sheet **20** are respectively provided at four corners of the upper peripheral wall **23** in a planar view. In other words, such a configuration is made that each upper alignment hole **24** is disposed to be overlapped with each of the above-described lower alignment holes **15** at the time of temporary joint which will be described later, which allows positioning between the lower metallic sheet **10** and the upper metallic sheet **20**.

[0123] The lower metallic sheet **10** and the upper metallic sheet **20** are permanently joined to each other preferably by the diffused junction. More specifically, as shown in FIG. **3**, an upper surface **14a** of the lower peripheral wall **14** of the lower metallic sheet **10** abuts a lower surface **23a** of the upper peripheral wall **23** of the upper metallic sheet **20**, so that the lower peripheral wall **14** and the upper peripheral wall **23** are joined to each other. Thereby, the sealed space **3** which seals the working fluid **2** is formed between the lower metallic sheet **10** and the upper metallic sheet **20**.

Also, the upper surface **13a** of each lower flow path wall portion **13** of the lower metallic sheet **10** abut the lower surface **22a** of each upper flow path wall portion **22** of the upper metallic sheet **20**, so that each lower flow path wall portion **13** and the corresponding upper flow path wall portion **22** are joined to each other. This improves the mechanical strength of the vapor chamber **1**. Especially, since the lower flow path wall portions **13** and the upper flow path wall portions **22** according to this embodiment are disposed with even intervals, the mechanical strength at each portion of the vapor chamber **1** can be equalized. Additionally, the lower metallic sheet **10** and the upper metallic sheet **20** may be joined by other methods such as brazing as long as permanent jointing is performed, not by the diffused junction.

[0124] Also, as shown in FIG. **2**, the vapor chamber **1** further includes an injection portion **4** for pouring the working fluid **2** in the sealed space **3** at one of a pair of ends in the first direction **X**. The injection portion **4** includes a lower injection protruding portion **16** which protrudes from an end surface of the lower metallic sheet **10** and an upper injection protruding portion **25** which protrudes from an end surface of the upper metallic sheet **20**. In these components, a lower injection flow path recess **17** is formed on an upper surface of the lower injection protruding portion **16**, and the upper injection flow path recess **26** is formed on a lower surface of the upper injection protruding portion **25**. The lower injection flow path recess **17** communicates with the lower vapor flow path recess **12**, and the upper injection flow path recess **26** communicates with the upper vapor flow path recess **21**. The lower injection flow path recess **17** and the upper injection flow path recess **26** form an injection flow path of the working fluid **2** when the lower metallic sheet **10** and the upper metallic sheet **20** are joined. The working fluid **2** passes through the injection flow path and is poured into the sealed space **3**. Additionally, in this embodiment, while an example in which the injection portion **4** is provided at one of the pair of ends of the vapor chamber **1** in the first direction **X**, this is not restrictive.

[0125] Next, the liquid flow path portion **30** of the lower metallic sheet **10** will be explained in more detail using FIGS. **3**, **4**, **6** and **7**.

[0126] As show in FIGS. **3** and **4**, the liquid flow path portion **30** through which the working fluid **2** in liquid form passes is provided in the upper surface **10a** of the lower metallic sheet **10** (more specifically, the upper surface **13a** of each lower flow path wall portion **13**). The liquid flow path portion **30** constitutes a part of the above-described sealed space **3**, and communicates with the lower vapor flow path recess **12** and the upper vapor flow path recess **21** described above.

[0127] As shown in FIG. **6**, the liquid flow path portion **30** include a first main flow groove **31**, a second main flow groove **32**, a third main flow groove **33** and a fourth main flow groove **34**. The first main flow groove **31** to the fourth main flow groove **34** respectively linearly extend in the first

direction X to allow the working fluid 2 in liquid form to pass through, and are arranged in this order in the second direction Y described above. In other words, the fourth main flow groove 34 is arranged on an opposite side from the second main flow groove 32 with respect to the third main flow groove 33. The first main flow groove 31 to the fourth main flow groove 34 are configured to mainly transport the working fluid 2, condensed from the vapor generated at the evaporating portion 11, to the evaporating portion 11.

[0128] A first convex array 41 is provided between the first main flow groove 31 and the second main flow groove 32. The first convex array 41 includes a plurality of first convex portions 41a arranged in the first direction X. In FIG. 6, each first convex portion 41a is formed to be rectangular such that the first direction X coincides with a longitudinal direction in a planar view. A first communicating groove 51 is interposed between the first convex portions 41a adjacent to each other. The first communicating groove 51 is formed to extend in the second direction Y to allow communication between the first main flow groove 31 and the second main flow groove 32, and the working fluid 2 can reciprocate between the first main flow groove 31 and the second main flow groove 32. The first communicating groove 51 is a region between the first convex portions 41a adjacent to each other, and a region between the first main flow groove 31 and the second main flow groove 32.

[0129] A second convex array 42 is provided between the second main flow groove 32 and the third main flow groove 33. The second convex array 42 includes a plurality of second convex portions 42a arranged in the first direction X. In FIG. 6, each second convex portion 42a is formed to be rectangular such that the first direction X coincides with a longitudinal direction in a planar view. A second communicating groove 52 is interposed between the second convex portions 42a adjacent to each other. The second communicating groove 52 is formed to extend in the second direction Y to allow communication between the second main flow groove 32 and the third main flow groove 33, and the working fluid 2 can reciprocate between the second main flow groove 32 and the third main flow groove 33. The second communicating groove 52 is a region between the second convex portions 42a adjacent to each other, and a region between the second main flow groove 32 and the third main flow groove 33.

[0130] The second main flow groove 32 includes a first intersection P1 communicating with the first communicating groove 51 and a second intersection P2 communicating with the second communicating groove 52.

[0131] In these components, at the first intersection P1, at least a part of the first communicating groove 51 faces the second convex portion 42a. As shown in FIG. 6, at the first intersection P1, the entire first communicating groove 51 (an entire region of the first communicating groove 51 in a width direction (the first direction X)) faces the second convex portion 42a. Thereby, over the entire first intersection P1, in a pair of side walls 35, 36 along the first direction X of the second main flow groove 32, the side wall 36 on an opposite side from the first communicating groove 51 (a wall of each second convex portion 42a) is disposed. In a form shown in FIG. 6, seen from the second direction Y, the first communicating groove 51 is disposed to be overlapped with the center of each second convex portion 42a in the first direction X. In this way, at the first intersection P1, the second main flow groove 32 and the first communicating groove 51 intersect to form a T shape. The first intersection P1 is a region formed by main flow groove body portions 31a to 34a adjacent to each other in the first direction X, and a region formed by the communicating grooves 51 to 54 and the convex portions 41a to 44a adjacent to each other in the second direction Y. In other words, this is a region in which the main flow grooves 31 to 34 and the communicating grooves 51 to 54 intersect (that is, an overlapping region). Here, the main flow groove body portions 31a to 34a constitute a part of the first main flow groove 31 to the fourth main flow groove 34, and are portions provided between the first intersection P1 and the second intersection P2, and portions positioned between the convex portions 41a to 44a adjacent to each other.

[0132] In the same manner, at the second intersection P2, at least a part of the second

communicating groove 52 faces the first convex portion 41a. As shown in FIG. 6, at the second intersection P2, the entire second communicating groove 52 (an entire region of the second communicating groove 52 in the width direction (the first direction X)) faces each first convex portion 41a. Thereby, over the entire second intersection P2, in a pair of side walls 35, 36 along the first direction X of the second main flow groove 32, the side wall 35 on an opposite side from the second communicating groove 52 (a wall of each first convex portion 41a) is disposed. In the form shown in FIG. 6, seen from the second direction Y, the second communicating groove 52 is disposed to be overlapped with the center of the first convex portion 41a in the first direction X. In this way, at the second intersection P2, the second main flow groove 32 and the second communicating groove 52 intersect to form a T shape. The second intersection P2 is a region formed by the main flow groove body portions 31a to 34a adjacent to each other in the first direction X, and a region formed by the communicating grooves 51 to 54 and the convex portions 41a to 44a adjacent to each other in the second direction Y. In other words, this is a region in which the main flow grooves 31 to 34 and the communicating grooves 51 to 54 intersect (that is, an overlapping region).

[0133] As described above, at the first intersection P1 of the second main flow groove 32, the first communicating groove 51 faces each second convex portion 42a, and at the second intersection P2 of the second main flow groove 32, the second communicating groove 52 faces each first convex portion 41a. As a result, the first communicating groove 51 and the second communicating groove 52 are not disposed in a straight line. In other words, the first communicating groove 51 communicating with the second main flow groove 32 on one side and the second communicating groove 52 communicating with the second main flow groove 32 on the other side are not disposed in the straight line.

[0134] In this embodiment, each first convex portion 41a and each second convex portion 42a have the same shape, and an arrangement pitch of the first convex portions 41a is the same as that of the second convex portions 42a. Moreover, the first convex portions 41a and the second convex portions 42a are arranged to be shifted to each other in the first direction X by a dimension which is a half of this arrangement pitch.

[0135] Also, in this embodiment, the first intersection P1 and the second intersection P2 of the second main flow groove 32 are adjacent to each other. In other words, no other intersection (for example, a third intersection P3 as shown in FIG. 14 which will be described later) is interposed between the first intersection P1 and the second intersection P2. Moreover, the second main flow groove 32 includes a plurality of first intersections P1 and a plurality of second intersections P2, and each first intersection P1 and each second intersection P2 are alternately arranged in the first direction X. In other words, the pair of side walls 35, 36 of the second main flow groove 32 is intermittently formed, and dividing positions of each of the side walls 35, 36 are shifted to each other in the first direction X.

[0136] Incidentally, a third convex array 43 is provided between the third main flow groove 33 and the fourth main flow groove 34. In the same manner as the first convex array 41, the third convex array 43 includes a plurality of third convex portions 43a arranged in the first direction X. A third communicating groove 53 is interposed between the third convex portions 43a adjacent to each other. The third communicating groove 53 is formed to extend in the second direction Y to allow communication between the third main flow groove 33 and the fourth main flow groove 34, and the working fluid 2 can reciprocate between the third main flow groove 33 and the fourth main flow groove 34. The third communicating groove 53 is a region formed by the third convex portions 43a adjacent to each other, and a region formed by the third main flow groove 33 and the fourth main flow groove 34.

[0137] The third main flow groove 33 includes the first intersection P1 communicating with the second communicating groove 52 and the second intersection P2 communicating with the third communicating groove 53. In these components, at the first intersection P1, at least a part of the

second communicating groove 52 faces each third convex portion 43a. As shown in FIG. 6, at the first intersection P1, the entire second communicating groove 52 (an entire region of the second communicating groove 52 in the width direction (the first direction X)) faces each third convex portion 43a. Thereby, over the entire first intersection P1, in a pair of side walls 35, 36 along the first direction X of the third main flow groove 33, the side wall 36 on an opposite side from the second communicating groove 52 (a wall of each third convex portion 43a) exists. In the form shown in FIG. 6, seen from the second direction Y, the second communicating groove 52 is disposed to be overlapped with the center of each third convex portion 43a in the first direction X. In this way, at the first intersection P1, the third main flow groove 33 and the second communicating groove 52 intersect to form a T shape.

[0138] In the same manner, at the second intersection P2, at least a part of the third communicating groove 53 faces each second convex portion 42a. In FIG. 6, at the second intersection P2, the entire of the third communicating groove 53 (an entire region of the third communicating groove 53 in the width direction (the first direction X)) faces each second convex portion 42a. Thereby, over the entire second intersection P2, in the pair of side walls 35, 36 along the first direction X of the third main flow groove 33, the side wall 35 on an opposite side from the third communicating groove 53 (a wall of each second convex portion 42a) is disposed. In the form shown in FIG. 6, seen from the second direction Y, the third communicating groove 53 is disposed to be overlapped with the center of each second convex portion 42a in the first direction X. In this way, at the second intersection P2, the third main flow groove 33 and the third communicating groove 53 intersect to form a T shape.

[0139] In other words, in this embodiment, each first convex portion 41a, each second convex portions 42a and each third convex portion 43a have the same shape, and the first convex portions 41a, the second convex portions 42a and the third convex portions 43a have the same arrangement pitch. Moreover, each second convex portion 42a and each third convex portion 43a are arranged to be shifted to each other in the first direction X by a dimension which is a half of this arrangement pitch. As a result, each first convex portion 41a and each third convex portion 43a are arranged at the same position in the first direction X, and seen in the second direction Y, each first convex portion 41a and each third convex portion 43a are overlapped.

[0140] In this embodiment, in the same manner as the second main flow groove 32, the first intersection P1 and the second intersection P2 of the third main flow groove 33 are adjacent to each other. Moreover, the third main flow groove 33 includes the plurality of first intersections P1 and the plurality of second intersections P2, and each first intersection P1 and each second intersection P2 are alternately arranged in the first direction X. In other words, the pair of side walls 35, 36 of the third main flow groove 33 is intermittently formed, and dividing positions of each of the side walls 35, 36 are shifted to each other in the first direction X.

[0141] Since the first convex portions 41a, the second convex portions 42a and the third convex portions 43a are disposed as described above, in this embodiment, the first convex portions 41a, the second convex portions 42a and the third convex portions 43a have a staggered arrangement. As a result, the first communicating groove 51, the second communicating groove 52 and the third communicating groove 53 have the staggered arrangement.

[0142] FIG. 6 shows one set of main flow grooves when the above-described first main flow groove 31 to the fourth main flow groove 34 are defined as one set. This set may be plural, so that multiple main flow grooves 31 to 34 may be formed on the upper surface 13a of each lower flow path wall portion 13 as a whole. Additionally, in the main flow grooves constituting the liquid flow path portion 30, the first main flow groove 31 to the fourth main flow groove 34 do not necessarily constitute one set, and any number of main flow grooves may be applied, not limited to a multiple of four, as long as at least three main flow grooves are formed.

[0143] In this case, on a side of the fourth main flow groove 34 opposite from the third main flow groove 33, the above-described first main flow groove 31 is provided, and a fourth convex array 44

is provided between the fourth main flow groove **34** and the first main flow groove **31**. In the same manner as the second convex array **42**, the fourth convex array **44** includes a plurality of fourth convex portions **44a** arranged in the first direction X. The fourth convex portions **44a** and the second convex portions **42a** are arranged at the same positions in the first direction X, and seen in the second direction Y, each fourth convex portion **44a** and each second convex portion **42a** are overlapped. A fourth communicating groove **54** is interposed between the third convex portions **43a** adjacent to each other. The fourth communicating groove **54** is formed to extend in the second direction Y to allow communication between the fourth main flow groove **34** and the first main flow groove **31**, and the working fluid **2** can reciprocate between the fourth main flow groove **34** and the first main flow groove **31**. The fourth communicating groove **54** is a region between the fourth convex portions **44a** adjacent to each other, and a region between the fourth main flow groove **34** and the first main flow groove **31**.

[0144] The fourth main flow groove **34** includes the first intersection **P1** and the second intersection **P2** in the same manner as the second main flow groove **32**. Here, at the first intersection **P1**, the fourth main flow groove **34** communicates with the third communicating groove **53**, and at the second intersection **P2**, the fourth main flow groove **34** communicates with the fourth communicating groove **54**. Also, the first main flow groove **31** includes the first intersection **P1** and the second intersection **P2** in the same manner as the third main flow groove **33**. Here, at the first intersection **P1**, the first main flow groove **31** communicates with the fourth communicating groove **54**, and at the second intersection **P2**, the first main flow groove **31** communicates with the first communicating groove **51**. Since the first intersection **P1** and the second intersection **P2** in the first main flow groove **31** and the fourth main flow groove **34** are similar to the first intersection **P1** and the second intersection **P2** in the second main flow groove **32** and the third main flow groove **33**, a detailed explanation thereof is omitted here.

[0145] Each of the convex portions **41a** to **44a** may be rectangular and have the staggered arrangement as described above over the entire liquid flow path portion **30**.

[0146] Incidentally, a width **w1** of the first main flow groove **31** to the fourth main flow groove **34** (a dimension in the second direction Y) is preferably larger than a width **w2** of each first convex portion **41a** to each fourth convex portion **44a** (a dimension in the second direction Y.) In such a case, the ratio of the first to fourth main flow grooves **31** to **34** to the upper surface **13a** of each lower flow path wall portion **13** can be made larger. Consequently, a flow path density of the main flow grooves **31** to **34** on the upper surface **13a** can be increased to improve a transport function of the working fluid **2** in liquid form. For example, the width **w1** of the first main flow groove **31** to the fourth main flow groove **34** may be 30 μm to 200 μm , and the width **w2** of each first convex portion **41a** to each fourth convex portion **44a** may be 20 μm to 180 μm .

[0147] A depth **h1** of the first main flow groove **31** to the fourth main flow groove **34** is preferably smaller than a depth **h0** of the above-described lower vapor flow path recess **12**. In such a case, capillary action of the first main flow groove **31** to the fourth main flow groove **34** can be improved. For example, the depth **h1** of the first main flow groove **31** to the fourth main flow groove **34** is preferably about a half of the depth **h0**, and may be 5 μm to 180 μm .

[0148] Also, a width **w3** of the first communicating groove **51** to the fourth communicating groove **54** (a dimension in the first direction X) is preferably smaller than the width **w1** of the first main flow groove **31** to the fourth main flow groove **34**. In such a case, during a period that the working fluid **2** in liquid form is transported toward the evaporating portion **11** in each of the main flow grooves **31** to **34**, the working fluid **2** is inhibited from flowing to the communicating grooves **51** to **54**, which improves the transport function of the working fluid **2**. On the other hand, when dryout occurs at any of the main flow grooves **31** to **34**, the working fluid **2** can be moved from the main flow grooves **31** to **34** adjacent thereto via the corresponding communicating grooves **51** to **54**, and accordingly, the dryout is immediately eliminated to secure the transport function of the working fluid **2**. In other words, as long as passage through the main flow grooves **31** to **34** adjacent to each

other is allowed, the first communicating groove **51** to the fourth communicating groove **54** can exert a function even if they have a smaller width than the width **w1** of the main flow grooves **31** to **34**. The width **w3** of such first communicating groove **51** to fourth communicating groove **54** may be 20 μm to 180 μm , for example.

[0149] The depth **h3** of the first communicating groove **51** to the fourth communicating groove **54** may be shallower than the depth **h1** of the first main flow groove **31** to the fourth main flow groove **34** in accordance with the width **w3** thereof. For example, the depth **h3** of the first communicating groove **51** to the fourth communicating groove **54** (not shown) may be 40 μm assuming that the depth **h1** of the first main flow groove **31** to the fourth main flow groove **34** is 50 μm .

[0150] Here, a method of confirming the width and the depth of the main flow grooves **31** to **34** and the width and the depth of the communicating grooves **51** to **54** from the vapor chamber **1** in a finished form will be described later.

[0151] The shape of a cross section (a cross section in the second direction **Y**) of the first main flow groove **31** to the fourth main flow groove **34** is not particularly limited, and for example, may be rectangular, curved, semi-circular or V-shaped. The same is applied to the shape of a cross section (a cross section in the first direction **X**) of the first communicating groove **51** to the fourth communicating groove **54**. In FIG. 7, an example in which the cross section of the first main flow grooves **31** to the fourth main flow groove **34** is formed to be rectangular is shown.

[0152] Incidentally, the above-described liquid flow path portion **30** is formed on the upper surface **13a** of each lower flow path wall portion **13** of the lower metallic sheet **10**. On the other hand, in this embodiment, the lower surface **22a** of each upper flow path wall portion **22** of the upper metallic sheet **20** is formed to be planar. Thereby, each of the main flow grooves **31** to **34** of the liquid flow path portion **30** is covered by the lower surface **22a** which is planar. In this case, as shown in FIG. 7, by the pair of side walls **35**, **36** extending in the first direction **X** of the main flow grooves **31** to **34** and the lower surface **22a** of each upper flow path wall portion **22**, two corner portions **37** in a right angle or an acute angle can be formed, which improves capillary action at the two corner portions **37**. In other words, while two corner portions **38** can be formed also by a bottom surface of the main flow grooves **31** to **34** (a surface on the side of the lower surface **10b** of the lower metallic sheet **10**) and the pair of side walls **35**, **36** of the main flow grooves **31** to **34**, when the main flow grooves **31** to **34** are formed by etching as will be described later, the corner portions **38** on the side of the bottom surface tend to be formed to be rounded. Consequently, capillary action can be improved at the corner portions **37** on a side of the lower surface **22a** of each upper flow path wall portion **22** by forming the lower surface **22a** of each upper flow path wall portion **22** to be planar to cover the main flow grooves **31** to **34** and the communicating grooves **51** to **54**. Additionally, in FIG. 7, for clarity of the figure, the side walls **35**, **36** and the corner portions **37**, **38** are shown only with respect to the first main flow groove **31**, and the side walls **35**, **36** and the corner portions **37**, **38** are omitted with respect to the second main flow groove **32** to the fourth main flow groove **34**.

[0153] Additionally, while a material used for the lower metallic sheet **10** and the upper metallic sheet **20** is not especially limited as long as the material has a good thermal conductivity, for example, the lower metallic sheet **10** and the upper metallic sheet **20** are preferably formed by copper (an oxygen-free copper) or copper alloy. This improves thermal conductivity of the lower metallic sheet **10** and the upper metallic sheet **20**. As a result, heat release efficiency of the vapor chamber **1** can be improved. Alternatively, as long as a desired heat release efficiency can be obtained, other metallic materials such as aluminum or other metallic alloy materials such as stainless steel may be used for these metallic sheets **10** and **20**.

[0154] Next, an operation of this embodiment constituted by such configuration will be explained. Here, firstly, a manufacturing method of the vapor chamber **1** will be explained using FIGS. **8** to **13**, but an explanation of a half etching step of the upper metallic sheet **20** is simplified. Additionally, in FIGS. **8** to **13**, the same cross section as in FIG. **3** is shown.

[0155] Firstly as shown in FIG. 8, as a preparation step, a planar metal material sheet M is prepared.

[0156] After that, as shown in FIG. 9, the metal material sheet M is half-etched to form the lower vapor flow path recess **12** constituting a part of the sealed space **3**. In this case, firstly, a not shown first resist film is formed to have a pattern corresponding to the plurality of lower flow path wall portions **13** and the lower peripheral wall **14** by a photolithographic technique on an upper surface Ma of the metal material sheet M. Thereafter, as a first half etching step, the upper surface Ma of the metal material sheet M is half-etched. Thereby, a portion of the upper surface Ma of the metal material sheet M corresponding to a resist opening (not shown) of the first resist film is half-etched, and the lower vapor flow path recess **12**, the lower flow path wall portions **13** and the lower peripheral wall **14** as shown in FIG. 9 are formed. At this time, the lower injection flow path recess **17** as shown in FIGS. 2 and 4 is simultaneously formed, and the metal material sheet M is etched to have an outer shape as shown in FIG. 4 from the upper surface Ma and a lower surface, thereby a predetermined outer shape can be obtained. After the first half etching step, the first resist film is removed. Additionally, the half etching means etching to form a recess not penetrating through a material. Consequently, the depth of the recess formed by the half etching is not limited to a half of the thickness of the lower metallic sheet **10**. As etching liquid, for example, ferric chloride etching liquid such as aqueous ferric chloride, or copper chloride etching liquid such as aqueous copper chloride can be used.

[0157] After the lower vapor flow path recess **12** is formed, as shown in FIG. 10, the liquid flow path portion **30** is formed on the upper surface **13a** of each lower flow path wall portion **13**.

[0158] In this case, firstly, a not shown second resist film is formed to have a pattern corresponding to the first convex portions **41a** to the fourth convex portions **44a** of the liquid flow path portion **30** by the photolithographic technique on the upper surface **13a** of each lower flow path wall portion **13**. After that, as a second half etching step, the upper surface **13a** of each lower flow path wall portion **13** is half-etched. Thereby, a portion of the upper surface **13a** corresponding to a resist opening (not shown) of the second resist film is half-etched, and the liquid flow path portion **30** is formed on the upper surface **13a** of each lower flow path wall portion **13**. In other words, on the upper surface **13a**, each of the convex portions **41a** to **44a** is formed. By these convex portions **41a** to **44a**, the first main flow groove **31** to the fourth main flow groove **34** and the first communicating groove **51** to the fourth communicating groove **54** are defined. After the second half etching step, the second resist film is removed.

[0159] In this way, the lower metallic sheet **10** formed with the liquid flow path portion **30** is obtained. Additionally, by forming the liquid flow path portion **30** as the second half etching step as a different step from the first half etching step, the main flow grooves **31** to **34** and the communicating grooves **51** to **54** can be easily formed with a depth which is different from the depth **h0** of the lower vapor flow path recess **12**. However, the lower vapor flow path recess **12** and the main flow grooves **31** to **34** as well as the communicating grooves **51** to **54** may be formed with the same half etching step. In such a case, the number of half etching step can be reduced, which can reduce a manufacturing cost of the vapor chamber **1**.

[0160] On the other hand, in the same manner as the lower metallic sheet **10**, the upper metallic sheet **20** is half-etched from the lower surface **20a** to form the upper vapor flow path recess **21**, the upper flow path wall portions **22** and the upper peripheral wall **23**. In this way, the above-described upper metallic sheet **20** is obtained.

[0161] Next, as shown in FIG. 11, as a temporary joint step, the lower metallic sheet **10** having the lower vapor flow path recess **12** and the upper metallic sheet **20** having the upper vapor flow path recess **21** are temporarily joined. In such a case, firstly, using the lower alignment holes **15** of the lower metallic sheet **10** (see FIGS. 2 and 4) and the upper alignment holes **24** of the upper metallic sheet **20** (see FIGS. 2 and 5), positioning of the lower metallic sheet **10** and the upper metallic sheet **20** is executed. Thereafter, the lower metallic sheet **10** and the upper metallic sheet **20** are

fixed. While a fixing method is not particularly limited, for example, the lower metallic sheet **10** and the upper metallic sheet **20** are fixed by executing resistance welding to the lower metallic sheet **10** and the upper metallic sheet **20**. In this case, as shown in FIG. **11**, a resistance spot welding is preferably executed using an electrode rod **40**. Instead of resistance welding, laser welding may be executed. Alternatively, ultrasonic junction may be executed to fix the lower metallic sheet **10** and the upper metallic sheet **20** by irradiating ultrasonic waves. Further, an adhesive agent may be used, and the adhesive agent including no or little organic constituent is preferably used. In this way, the lower metallic sheet **10** and the upper metallic sheet **20** are fixed with execution of the positioning.

[0162] After the temporary joint, as shown in FIG. **12**, as a permanent joint step, the lower metallic sheet **10** and the upper metallic sheet **20** are permanently joined by the diffused junction. The diffused junction is a method in which the lower metallic sheet **10** and the upper metallic sheet **20** to be joined are closely contacted, and each of the metallic sheets **10**, **20** is pressurized to be heated in a contact direction in a controlled atmosphere such as vacuum or inert gas to execute joint using diffusion of atoms generated at joint surfaces. While the material of the lower metallic sheet **10** and the upper metallic sheet **20** are heated to a temperature approximate to a melting point in the diffused junction, this temperature is lower than the melting point, which avoids melting and deformation of each of the metallic sheets **10**, **20**. More specifically, the upper surface **14a** of the lower peripheral wall **14** of the lower metallic sheet **10** and the lower surface **23a** of the upper peripheral wall **23** of the upper metallic sheet **20** are subjected to the diffused junction as joint surfaces. Thereby, by the lower peripheral wall **14** and the upper peripheral wall **23**, the sealed space **3** is formed between the lower metallic sheet **10** and the upper metallic sheet **20**. Also, by the lower injection flow path recess **17** (see FIGS. **2** and **4**) and the upper injection flow path recess **26** (see FIGS. **2** and **5**), an injection flow path of the working fluid **2** communicating with the sealed space **3** is formed. Further, the upper surface **13a** of each lower flow path wall portion **13** of the lower metallic sheet **10** and the lower surface **22a** of each upper flow path wall portion **22** of the upper metallic sheet **20** are subjected to the diffused junction as joint surfaces, so that mechanical strength of the vapor chamber **1** is improved. The liquid flow path portion **30** formed on the upper surface **13a** of each lower flow path wall portion **13** remains as a flow path of the working fluid **2** in liquid form.

[0163] After the permanent joint, as shown in FIG. **13**, as an enclosing step, the working fluid **2** is poured into the sealed space **3** from the injection portion **4** (see FIG. **2**). At this time, firstly, the sealed space **3** is depressurized by vacuuming, and then the working fluid **2** is poured into the sealed space **3**. At the time of injection, the working fluid **2** passes through the injection flow path formed by the lower injection flow path recess **17** and the upper injection flow path recess **26**. For example, while the enclosing amount of the working fluid **2** depends on the configuration of the liquid flow path portion **30** in the vapor chamber **1**, it may be 10% to 30% to the entire volume of the sealed space **3**.

[0164] After the injection of the working fluid **2**, the above-described injection flow path is sealed. For example, a laser may be irradiated to the injection portion **4** to seal the injection flow path by partially melting the injection portion **4**. Thereby, communication between the sealed space **3** and the outside is blocked, and the working fluid **2** is enclosed in the sealed space **3**. This prevents leaking of the working fluid **2** in the sealed space **3** to the outside. Additionally, for sealing, swaging or brazing of the injection portion **4** may be executed.

[0165] As described above, the vapor chamber **1** according to this embodiment can be obtained.

[0166] Next, an operation method of the vapor chamber **1**, that is, a cooling method of the device **D** will be explained.

[0167] The vapor chamber **1** thus obtained is installed in the housing **H** of the mobile terminal etc., and the device **D** such as the CPU which is an object of cooling is attached to the lower surface **10b** of the lower metallic sheet **10**. Since the amount of the working fluid **2** poured into the sealed space

3 is small, the working fluid 2 in liquid form in the sealed space 3 attaches to a wall surface of the sealed space 3, that is, a wall surface of the lower vapor flow path recess 12, a wall surface of the upper vapor flow path recess 21 and a wall surface of the liquid flow path portion 30 by surface tension thereof.

[0168] When the device D generates heat in this state, the working fluid 2 existing at the evaporating portion 11 in the lower vapor flow path recess 12 receives the heat from the device D. The received heat is absorbed as latent heat and the working fluid 2 evaporates (vaporization) to generate the vapor of the working fluid 2. Most of the generated vapor diffuses in the lower vapor flow path recess 12 and the upper vapor flow path recess 21 constituting the sealed space 3 (see solid arrows of FIG. 4). The vapor in the upper vapor flow path recess 21 and the lower vapor flow path recess 12 is separated from the evaporating portion 11, and most of the vapor is transported to a peripheral portion of the vapor chamber 1 with a relatively low temperature. The diffused vapor is subjected to heat dissipation to the lower metallic sheet 10 and the upper metallic sheet 20 to be cooled. The heat received by the lower metallic sheet 10 and the upper metallic sheet 20 from the vapor is transferred to the outside via the housing member Ha (see FIG. 3).

[0169] Since the vapor is subjected to heat dissipation to the lower metallic sheet 10 and the upper metallic sheet 20, the vapor loses the latent heat absorbed in the evaporating portion 11 and is condensed. The working fluid 2 in a liquid form by condensation is attached to the wall surfaces of the lower vapor flow path recess 12 or the wall surfaces of the upper vapor flow path recess 21. Here, since the working fluid 2 continues to be evaporated at the evaporating portion 11, the working fluid 2 at portions other than the evaporating portion 11 in the liquid flow path portion 30 is transported toward the evaporating portion 11 (see dashed arrows in FIG. 4). As a result, the working fluid 2 in liquid form attached to the wall surfaces of the lower vapor flow path recess 12 and the wall surfaces of the upper vapor flow path recess 21 moves toward the liquid flow path portion 30 and is inserted into the liquid flow path portion 30. In other words, the working fluid 2 is inserted into the first main flow groove 31 to the fourth main flow groove 34 via the first communicating groove 51 to the fourth communicating groove 54, so that the first main flow groove 31 to the fourth main flow groove 34 and the first communicating groove 51 to the fourth communicating groove 54 are filled with the working fluid 2 in liquid form. Consequently, due to capillary action of each of the main flow grooves 31 to 34, the working fluid 2 which is filled obtains thrust toward the evaporating portion 11, and is smoothly transported to the evaporating portion 11.

[0170] At the liquid flow path portion 30, in the main flow grooves 31 to 34, one communicates with another which is adjacent thereto via the corresponding communicating grooves 51 to 54. Thereby, the working fluid 2 in liquid form reciprocates between the main flow grooves 31 to 34 adjacent to each other, which inhibits occurrence of dryout in the main flow grooves 31 to 34. Accordingly, capillary action is applied to the working fluid 2 in each of the main flow grooves 31 to 34, so that the working fluid 2 is smoothly transported toward the evaporating portion 11.

[0171] Also, since each of the main flow grooves 31 to 34 includes the above-described first intersection P1 and the second intersection P2, loss of capillary action acting on the working fluid 2 in each of the main flow grooves 31 to 34 is prevented. Here, in a case where the first communicating groove 51 and the second communicating groove 52 are arranged in the straight line via the second main flow groove 32 for example, both of the pair of side walls 35, 36 do not exist at an intersection with the second main flow groove 32. In such a case, capillary action in a direction toward the evaporating portion 11 is lost at the intersection, which can reduce the thrust of the working fluid 2 toward the evaporating portion 11.

[0172] On the other hand, in this embodiment, as described above, the first communicating groove 51 communicating with the second main flow groove 32 on one side and the second communicating groove 52 communicating therewith on the other side are not arranged on the straight line. In such a case, as shown FIG. 6, at the first intersection P1, in the pair of side walls

35, 36 along the first direction **X** of the second main flow groove **32**, the side wall **36** on an opposite side from the first communicating groove **51** is disposed. Thereby, at the first intersection **P1**, loss of capillary action in the direction toward the evaporating portion **11** is prevented. In the same matter, also at the second intersection **P2**, since the side wall **35** on an opposite side from the second communicating groove **52** is disposed, loss of capillary action in the direction toward the evaporating portion **11** is prevented. As a result, reduction of capillary action at each of the intersections **P1** and **P2** can be inhibited, so that the working fluid **2** toward the evaporating portion **11** can be continuously applied capillary action.

[0173] Moreover, in this embodiment, the first intersection **P1** and the second intersection **P2** of the second main flow groove **32** are alternately arranged. In other words, at the first intersection **P1** of the second main flow groove **32**, capillary action can be applied to the working fluid **2** in the second main flow groove **32** by the side wall **36** on a side of the second communicating groove **52**, while at the second intersection **P2**, capillary action can be applied to the working fluid **2** in the second main flow groove **32** by the side wall **35** on a side of the first communicating groove **51** on an opposite side from the side wall **36**. Consequently, capillary action acting on the working fluid **2** in the second main flow groove **32** can be equalized in the width direction (the second direction **Y**).

[0174] In this embodiment, each of the first main flow groove **31**, the third main flow groove **33** and the fourth main flow groove **34** has the first intersection **P1** and the second intersection **P2** in the same manner as the second main flow groove **32**. This inhibits reduction of capillary action applied to the working fluid **2** in the first main flow groove **31** to the fourth main flow groove **34**.

[0175] The working fluid **2** which has reached the evaporating portion **11** receives heat again from the device **D** to evaporate. In this way, the working fluid **2** circulates in the vapor chamber **1** while executing a change of phase, that is, repeating evaporation and condensation to transfer heat of the device **D** for releasing. As a result, the device **D** is cooled.

[0176] Incidentally, in this embodiment, as described above, in the second main flow groove **32**, the first communicating groove **51** and the second communicating groove **52** are not arranged on the same straight line. Consequently, depending on the attitude of the mobile terminal to which the vapor chamber **1** is installed, there is a case where the second direction **Y** is more similar to a direction of a gravitational force than the first direction **X**. With such attitude, if the first communicating groove **51** and the second communicating groove **52** are arranged on the same straight line, it is believed that a part of the working fluid **2** in each of the main flow grooves **31** to **34** is affected by the gravitational force to flow to one side in the second direction **Y** in each of the communicating grooves **51** to **54**, so that the working fluid **2** is shifted to the one side.

[0177] However, as in this embodiment, in a case where each of the main flow grooves **31** to **34** includes the first intersection **P1** and the second intersection **P2**, the working fluid **2** is inhibited from linearly flowing to one side in the second direction **Y**. In other words, the working fluid **2** can move to the evaporating portion **11** through the main flow grooves **31** to **34** while it is directed to the one side in the second direction **Y**, which inhibits weakening of a flow of the working fluid **2** to the evaporating portion **11**. Consequently, the transport function of the working fluid **2** in liquid form can be improved even if the vapor chamber **1** has an attitude in which a gravitational force acts in a direction of inhibiting the transport function of the working fluid **2**.

[0178] Incidentally, the sealed space **3** is depressurized as described above. Thereby, the lower metallic sheet **10** and the upper metallic sheet **20** receive pressure in a direction of being recessed inwardly from the outside air. Here, in a case where the first communicating groove **51** and the second communicating groove **52** are arranged on the straight line via the second main flow groove **32**, an intersection at which the second main flow groove **32**, the first communicating groove **51**, and the second communicating groove **52** intersect at a right angle is formed. In such a case, along a groove extending in the second direction **Y** orthogonal to the first direction **X**, the lower metallic sheet **10** and the upper metallic sheet **20** are recessed inwardly and the corresponding recess traversing the second main flow groove **32** is formed. In this case, a cross-sectional area of a flow

path of the second main flow groove **32** is reduced, which can increase flow path resistance of the working fluid **2**.

[0179] On the other hand, in this embodiment, at each of the first intersection **P1** of the second main flow groove **32**, the first communicating groove **51** faces each second convex portion **42a**. Thereby, even when the lower metallic sheet **10** and the upper metallic sheet **20** are recessed inwardly along the first communicating grooves **51**, the corresponding recess is prevented from traversing the second main flow groove **32**. This secures the cross-sectional area of the flow path of the second main flow groove **32**, and the flow of the working fluid **2** is prevented from being blocked. For example, in a vapor chamber for a mobile terminal requiring a thin body, due to its thinness, inhibiting concave deformation may be difficult. However, even when the vapor chamber **1** according to this embodiment is applied to such vapor chamber for a mobile terminal, according to this embodiment, concave deformation can be effectively inhibited. For example, when the thickness (remained thickness) of a portion of the lower metallic sheet **10** formed with the main flow grooves **31** to **34** and the communicating grooves **51** to **54** is about 50 μm to 150 μm , to inhibit concave deformation, it is contemplated that the staggered arrangement of the first convex portion **41a** to the fourth convex portion **44a** may be effective. Also, when the oxygen-free copper is used as a material with a good thermal conductivity, inhibition of concave deformation may be difficult due to a low mechanical strength of the material. However, the concave deformation can be effectively inhibited even when the vapor chamber **1** according to this embodiment is made by the oxygen-free copper.

[0180] In this way, according to this embodiment, as described above, at the first intersection **P1**, in the pair of side walls **35**, **36** of the second main flow groove **32**, the side wall **36** on an opposite side from the first communicating groove **51** can be disposed. Thereby, even when the lower metallic sheet **10** and the upper metallic sheet **20** are recessed inwardly along the first communicating groove **51** due to pressure of the outside air, the corresponding recess is prevented from traversing the second main flow groove **32**. In the same manner, at the second intersection **P2**, in the pair of side walls **35**, **36** of the second main flow groove **32**, the side wall **35** on an opposite side from the second communicating groove **52** can be disposed. Thereby, even when the lower metallic sheet **10** and the upper metallic sheet **20** are recessed inwardly along the first communicating groove **51** due to pressure of the outside air, the corresponding recess is prevented from traversing the second main flow groove **32**. This secures the cross-sectional area of the flow path of the second main flow groove **32**, and the flow of the working fluid **2** is prevented from being blocked. As a result, the transport function of the working fluid **2** in liquid form can be improved, and thermal transport efficiency can be improved.

[0181] Also, according to this embodiment, the second main flow groove **32** of the liquid flow path portion **30** includes the first intersection **P1** at which the first communicating groove **51** faces each second convex portion **42a** and the second intersection **P2** at which the second communicating groove **52** faces each first convex portion **41a**. Thereby, at the first intersection **P1**, in the pair of side walls **35**, **36** of the second main flow groove **32**, the side wall **36** on an opposite side from the first communicating groove **51** can be disposed, and at the second intersection **P2**, the side wall **35** on an opposite side from the second communicating groove **52** is disposed. Accordingly, capillary action can be continuously applied to the working fluid **2** toward the evaporating portion **11**. Also, the working fluid **2** in the second main flow groove **32** can be applied capillary action by the side walls **35**, **36** disposed at opposite sides from each other at the first intersection **P1** and the second intersection **P2**. Accordingly, capillary action applied to the working fluid **2** in the second main flow groove **32** can be equalized in the second direction **Y**. This inhibits reduction of the thrust of the working fluid **2** toward the evaporating portion **11** at the intersections **P1**, **P2**. As a result, the transport function of the working fluid **2** in liquid form can be improved, and thermal transport efficiency can be improved.

[0182] Also, according to this embodiment, the first intersection **P1** and the second intersection **P2**

of the second main flow groove **32** are adjacent to each other. Thereby, capillary action acting on the working fluid **2** in the second main flow groove **32** can be equalized in the width direction. [0183] Also, according to this embodiment, a plurality of first intersections **P1** and a plurality of second intersections **P2** are alternately arranged. Thereby, capillary action applied to the working fluid **2** in the second main flow groove **32** can be even more equalized.

[0184] Also, according to this embodiment, the liquid flow path portion **30** includes the third main flow groove **33**, and the third main flow groove **33** includes the first intersection **P1** at which the second communicating groove **52** faces each third convex portion **43a** and the second intersection **P2** at which the third communicating groove **53** faces each second convex portion **42a**. Thereby, in the same manner as the above-described second main flow groove **32**, even when the lower metallic sheet **10** and the upper metallic sheet **20** are recessed inwardly by the pressure of the outside air, the corresponding recess is prevented from traversing the third main flow groove **33**. Moreover, capillary action applied to the working fluid **2** in the third main flow groove **33** can be equalized. This secures the cross-sectional area of the flow path of the third main flow groove **33**. In particular, in this embodiment, the first main flow groove **31** and the fourth main flow groove **34** also include similar first intersection **P1** and second intersection **P2**. Accordingly, capillary action applied to the working fluid **2** over the entire of the liquid flow path portion **30** is equalized and the cross-sectional area of the flow path of each of the main flow grooves **31** to **34** can be secured, which can improve transport efficiency of the working fluid **2** even more.

[0185] Also, according to this embodiment, the first intersection **P1** and the second intersection **P2** of the third main flow groove **33** are adjacent to each other, so that one-sided application of capillary action can be inhibited even more. In particular, since the plurality of first intersections **P1** and the plurality of second intersections **P2** are alternately arranged, capillary action applied to the working fluid **2** in the third main flow groove **33** can be even further equalized.

[0186] Also, according to this embodiment, the lower surface **22a** of each upper flow path wall portion **22** of the upper metallic sheet **20** abutting the upper surface **13a** of each lower flow path wall portion **13** is planar to cover the second main flow groove **32**. Thereby, at a transverse section of each of the main flow grooves **31** to **34** and each of the communicating groove **51** to **54**, two corner portions **37** in a right angle or an acute angle (see FIG. 7) can be formed, which improves capillary action acting on the working fluid **2** in each of the main flow grooves **31** to **34** and each of the communicating grooves **51** to **54** can be improved.

[0187] Also, according to this embodiment, the width **w1** of the first main flow groove **31** to the fourth main flow groove **34** is larger than the width **w2** of the first convex portions **41a** to the fourth convex portions **44a**. This increases the ratio of the first to fourth main flow grooves **31** to **34** to the upper surface **13a** of each lower flow path wall portion **13**. As a result, the transport function of the working fluid **2** in liquid form can be improved.

[0188] Further, according to this embodiment, the width **w3** of the first communicating groove **51** to the fourth communicating groove **54** is smaller than the width **w1** of the first main flow groove **31** to the fourth main flow groove **34**. Thereby, during the period that the working fluid **2** in liquid form is transported toward the evaporating portion **11** in each of the main flow grooves **31** to **34**, the working fluid **2** is inhibited from flowing to the communicating grooves **51** to **54**, which improves the transport function of the working fluid **2**. On the other hand, when dryout occurs at any of the main flow grooves **31** to **34**, the working fluid **2** can be moved from the main flow grooves **31** to **34** adjacent thereto via the corresponding communicating grooves **51** to **54**, and accordingly, the dryout is immediately eliminated to secure the transport function of the working fluid **2**.

[0189] Additionally, in this embodiment described above, an example in which the entire of the first communicating groove **51** faces each second convex portion **42a** at the first intersection **P1** of the second main flow groove **32** and the entire of the second communicating groove **52** faces each first convex portion **41a** at the second intersection **P2** has been explained. However, not limited to

this, it is sufficient that a part of the first communicating groove **51** (a partial region of the first communicating groove **51** in the width direction (the first direction X)) faces each second convex portion **42a** at the first intersection **P1**. Moreover, it is sufficient that a part of the second communicating groove **52** faces the first convex portion **41a** at the second intersection **P2**. In other words, a partial overlapping is acceptable unless the first communicating groove **51** and the second communicating groove **52** are overlapped as a whole (unless the first communicating groove **51** and the second communicating groove **52** are arranged on the straight line) seen in the second direction Y. Even in this case, the side wall **36** of the second main flow groove **32** can be arranged at a part of the first intersection **P1** in the first direction X and the side wall **35** of the second main flow groove **32** can be arranged at a part of the second intersection **P2** in the first direction X. Thereby, at the first intersection **P1**, loss of capillary action in the direction toward the evaporating portion **11** is prevented. The same is applied to the first intersection **P1** and the second intersection **P2** in each of the first main flow groove **31**, the third main flow groove **33** and the fourth main flow groove **34**.

[0190] Also, in this embodiment described above, an example in which each of the first main flow groove **31** to the fourth main flow groove **34** includes the first intersection **P1** and the second intersection **P2** has been explained. However, not limited to this, it is sufficient that the first intersection **P1** and the second intersection **P2** may be included in at least one of the main flow grooves **31** to **34** of the liquid flow path portion **30**.

[0191] For example, the liquid flow path portion **30** may have a configuration as shown in FIG. **14**. In a form shown in FIG. **14**, the second main flow groove **32** and the fourth main flow groove **34** include the first intersection **P1** and the second intersection **P2** in the same manner as the form shown in FIG. **6**. However, the first main flow groove **31** and the third main flow groove **33** do not include the first intersection **P1** and the second intersection **P2** as in the form shown in FIG. **6**. In other words, in the first main flow groove **31**, the fourth communicating groove **54** and the first communicating groove **51** extending in the second direction Y are arranged in the straight line, and the third intersection **P3** in which the first main flow groove **31**, the fourth communicating groove **54** and the first communicating groove **51** intersect at a right angle is formed. In the same manner, also in the third main flow groove **33**, the second communicating groove **52** and the third communicating groove **53** extending in the second direction Y are arranged in the straight line, and the third intersection **P3** in which the third main flow groove **33**, the second communicating groove **52** and the third communicating groove **53** intersect at a right angle is formed. Even in such form, the second main flow groove **32** and the fourth main flow groove **34** include the first intersection **P1** and the second intersection **P2**, which improves the transport function of the working fluid **2** in liquid form in the liquid flow path portion **30**.

[0192] Also, in this embodiment described above, an example in which the plurality of first intersections **P1** and the plurality of second intersections **P2** are alternately arranged in each of the main flow grooves **31** to **34** has been explained. However, this is not restrictive. For example, the transport function of the working fluid **2** can be improved as long as one first intersection **P1** and one second intersection **P2** are included in each of the main flow grooves **31** to **34**. Further, while an example in which the first intersection **P1** and the second intersection **P2** are adjacent to each other in each of the main flow grooves **31** to **34** has been explained, this is not restrictive. For example, in each of the main flow grooves **31** to **34**, between the first intersection **P1** and the second intersection **P2**, an intersection in which the communicating grooves **51** to **54** on both sides are arranged in the straight line and the main flow grooves **31** to **34** and the communicating grooves **51** to **54** intersect at a right angle (for example, **P3** shown in FIG. **14**) may be formed. Even in this case, by the first intersection **P1** and the second intersection **P2**, the transport function of the working fluid **2** in liquid form in the liquid flow path portion **30** can be improved.

[0193] Also, in this embodiment described above, an example in which the first main flow groove **31** to the fourth main flow groove **34** and the first communicating groove **51** to the fourth

communicating groove **54** intersect at a right angle. However, not limited to this, the first main flow groove **31** to the fourth main flow groove **34** and the first communicating groove **51** to the fourth communicating groove **54** do not necessarily intersect at a right angle as long as they intersect with each other.

[0194] For example, as shown in FIG. **15**, a direction of alignment of the communicating grooves **51** to **54** may be inclined to the first direction X and the second direction Y. In this case, an inclining angle θ of the communicating grooves **51** to **54** to the first direction X is arbitrary. In an example shown in FIG. **15**, a planar shape of each of the convex portions **41a** to **44a** is a parallelogram. When such shape is applied to the vapor chamber **1** which is rectangular, four outer edges **1a**, **1b** (see FIG. **2**) constituting the planar outline of the vapor chamber **1** does not intersect at a right angle with the communicating grooves **51** to **54**. In such a case, deformation by bending along a line extending in the second direction Y is prevented, which prevents each of the grooves **31** to **34** and **51** to **54** of the liquid flow path portion **30** from being crushed.

[0195] Also, the first to fourth main flow grooves **31** to **34** are not necessarily linearly formed. For example, in FIG. **16**, the main flow grooves **31** to **34** are meandering, not linear, and extend in the first direction X in a large sense. More specifically, in the pair of side walls **35**, **36** of the main flow groove **31**, a curved concave portion and a curved convex portion are alternately arranged to be connected in a smoothly continuing manner. In a case where the main flow grooves **31** to **34** are formed as shown in FIG. **16**, a contact area between the working fluid **2** and the convex portions **41a** to **44a** increases, which improves cooling efficiency of the working fluid **2**.

[0196] Also, in this embodiment as described above, an example in which the convex portions **41a** to **44a** are rectangular and arranged in a staggered manner over the entire of each liquid flow path portion **30** has been explained. However, not limited to this, at least a part of the convex portions **41a** to **44a** may be arranged in a form as shown in FIG. **15** or **16** described above. Further, as for the convex portions **41a** to **44a**, at least two of the staggered arrangement as shown in FIG. **6**, the arrangement of FIG. **15** and the arrangement of FIG. **16** may be combined.

[0197] Also, in this embodiment described above, an example in which the first convex portion **41a**, the second convex portion **42a**, the third convex portion **43a** and the fourth convex portion **44a** have the same shape has been explained. However, not limited to this, the first convex portion **41a** to the fourth convex portion **44a** may have different shapes from each other.

[0198] For example, as shown in FIG. **17**, the length in the first direction X of the second convex portion **42a** and the fourth convex portion **44a** may be longer than that of the first convex portion **41a** and the third convex portion **43a**. In a form shown in FIG. **17**, in the second main flow groove **32** and the fourth main flow groove **34**, two first intersections **P1** are interposed between two second intersections **P2**. In other words, the first intersection **P1** and the second intersection **P2** are not alternately arranged as shown in FIG. **6**. Also, in the first main flow groove **31** and the third main flow groove **33**, two second intersections **P2** are interposed between two first intersections **P1**, and the first intersection **P1** and the second intersection **P2** are not alternately arranged. Also in this case, by the first intersection **P1** and the second intersection **P2**, the transport function of the working fluid **2** in liquid form in the liquid flow path portion **30** can be improved.

[0199] Also, in this embodiment described above, an example in which the upper flow path wall portions **22** of the upper metallic sheet **20** extend to be elongated along the first direction X of the vapor chamber **1** has been explained. However, not limited to this, the shape of the upper flow path wall portions **22** is arbitrary. For example, the upper flow path wall portions **22** may be formed as a cylindrical boss. Also in this case, preferably, each upper flow path wall portion **22** is arranged to be overlapped with each lower flow path wall portion **13** in a planar view, and the lower surface **22a** of each upper flow path wall portion **22** is allowed to abut the upper surface **13a** of each lower flow path wall portion **13**.

[0200] Also, in this embodiment described above, an example in which the upper metallic sheet **20** has the upper vapor flow path recess **21** has been explained. However, not limited to this, the upper

metallic sheet **20** may be formed to be planar as a whole, and does not necessarily have the upper vapor flow path recess **21**. In such a case, the lower surface **20a** of the upper metallic sheet **20** abuts the upper surface **13a** of the each lower flow path wall portion **13** as the second abutting surface, which improves mechanical strength of the vapor chamber **1**.

[0201] Also, in this embodiment described above, an example in which the lower metallic sheet **10** has the lower vapor flow path recess **12** and the liquid flow path portion **30** has been explained. However, not limited to this, if the upper metallic sheet **20** has the upper vapor flow path recess **21**, it is acceptable that the lower metallic sheet **10** does not have the lower vapor flow path recess **12** and the liquid flow path portion **30** is provided in the upper surface **10a** of the lower metallic sheet **10**. In such a case, as shown in FIG. **18**, a region formed with the liquid flow path portion **30** of the upper surface **10a** may be provided in, in addition to a region facing each upper flow path wall portion **22**, a region excluding each upper flow path wall portion **22** in a region facing the upper vapor flow path recess **21**. In such a case, the number of main flow grooves **31** to **34** constituting the liquid flow path portion **30** can be increased, which can improve the transport function of the working fluid **2** in liquid form. However, the region formed with the liquid flow path portion **30** is not limited to a form shown in FIG. **18**, and is arbitrary as long as the transport function of the working fluid **2** in liquid form can be secured. Also, in the form shown in FIG. **18**, the lower surface **22a** (an abutting surface) of each upper flow path wall portion **22** of the upper metallic sheet **20** is formed at a partial region of the lower surface **20a** of the upper metallic sheet **20** to secure a vapor flow path, and the lower surface **22a** of each upper flow path wall portion **22** abuts a part of the region formed with the liquid flow path portion **30** of the upper surface **10a** of the lower metallic sheet **10**.

[0202] Also, in this embodiment described above, an example in which the first main flow groove **31** to the fourth main flow groove **34** include the first intersection **P1** and the second intersection **P2** has been explained. However, not limited to this, even when each of the main flow grooves **31** to **34** does not include the intersections **P1** and **P2**, as long as the width **w1** of the first main flow groove **31** to the fourth main flow groove **34** is larger than the width **w2** of each first convex portion **41a** to each fourth convex portion **44a**, the ratio of the first to fourth main flow grooves **31** to **34** to the upper surface **13a** of each lower flow path wall portion **13** can be made larger. Also in such a case, the transport function of the working fluid **2** in liquid form can be improved, which improves thermal transport efficiency.

Second Embodiment

[0203] Next, a vapor chamber, an electronic device, a metallic sheet for the vapor chamber and a manufacturing method of the vapor chamber according to a second embodiment of the present invention will be explained using FIGS. **19** to **22**.

[0204] In the second embodiment as shown in FIGS. **19** to **22**, a main difference is that a width of the first to fourth communicating grooves is larger than a width of the first to fourth main flow grooves, and the other configurations are substantially similar to those in the first embodiment shown in FIGS. **1** to **18**. Additionally, in FIGS. **19** to **22**, the same components as in the first embodiment shown in FIGS. **1** to **18** are applied the same reference numerals, and a detailed explanation thereof is omitted.

[0205] As shown in FIG. **19**, in this embodiment, a width **w3'** of the first communicating groove **51** to the fourth communicating groove **54** is larger than the width **w1** of the first main flow groove **31** to the fourth main flow groove **34** (more specifically, the width of a first main flow groove body portion **31a** to a fourth main flow groove body portion **34a** which will be described later). The width **w3'** of the communicating grooves **51** to **54** may be, for example, 40 μm to 300 μm . In this embodiment, as shown in FIGS. **20** and **21**, an example in which the shape of a transverse section of each of the main flow grooves **31** to **34** and the shape of a transverse section of each of the communicating grooves **51** to **54** are formed to be curved will be explained. In such a case, the width of grooves **31** to **34** and **51** to **54** is the width of the grooves on the upper surface **13a** of each

lower flow path wall portion **13**. In the same manner, the width of convex portions **41a** to **44a** which will be described later is the width of the convex portions on the upper surface **13a**.

[0206] Incidentally, also in this embodiment, the lower surface **22a** of each upper flow path wall portion **22** of the upper metallic sheet **20** is formed to be planar. Thereby, the first main flow groove **31** to the fourth main flow groove **34** of the liquid flow path portion **30** are covered by the planar lower surface **22a**. In such a case, as shown in FIG. **20**, by the pair of side walls **35**, **36** extending in the first direction X of the main flow grooves **31** to **34** and the lower surface **22a** of each upper flow path wall portion **22**, two corner portions **37** in a right angle or an acute angle can be formed, which improves capillary action at the two corner portions **37**. In other words, even when the transverse section of each of the first to fourth main flow grooves **31** to **34** is formed to be curved, capillary action can be improved at the corner portions **37**.

[0207] In the same manner, the first to fourth communicating grooves **51** to **54** of the liquid flow path portion **30** are covered by the planar lower surface **22a**. In such a case, as shown in FIG. **21**, by the pair of side walls **55**, **56** extending in the second direction Y of the first to fourth communicating grooves **51** to **54** and the lower surface **22a** of each upper flow path wall portion **22**, two corner portions **57** in a right angle or an acute angle can be formed, which improves capillary action at the two corner portions **57**. In other words, even when the transverse section of each of the first to fourth communicating grooves **51** to **54** is formed to be curved, capillary action can be improved at the corner portions **57**.

[0208] Here, the working fluid **2** in liquid form condensed from the vapor passes through the first to fourth communicating grooves **51** to **54** to enter the first to fourth main flow grooves **31** to **34** which will be described later. Consequently, since capillary action of the first to fourth communicating grooves **51** to **54** is improved, the working fluid **2** condensed in liquid form is allowed to smoothly enter the first to fourth main flow grooves **31** to **34**. Due to capillary action of the first to fourth communicating grooves **51** to **54**, the working fluid **2** condensed in liquid form can smoothly enter not only the first main flow groove **31** at a closer side to the vapor flow path recesses **12**, **21**, but also the first to fourth main flow grooves **31** to **34** at a farther side from the vapor flow path recesses **12**, **21**, which improves the transport function of the working fluid **2** condensed in liquid form. Also, since the width $w3'$ of the first to fourth communicating grooves **51** to **54** is larger than the width $w1$ of the first to fourth main flow grooves **31** to **34**, the flow path resistance of the working fluid **2** in the first to fourth communicating grooves **51** to **54** can be reduced, and also in this point, the working fluid **2** condensed in liquid form is allowed to smoothly enter each of the first to fourth main flow grooves **31** to **34**. Moreover, the working fluid **2** entering the first to fourth main flow grooves **31** to **34** can be smoothly transported to the evaporating portion **11** due to capillary action of the first to fourth main flow grooves **31** to **34**. As a result, as the entire liquid flow path portion **30**, the transport function of the working fluid **2** in liquid form can be improved.

[0209] Also, both end portions in the first direction X of the first to fourth convex portions **41a** to **44a** are formed to be rounded in a planar view. In other words, although each of the convex portions **41a** to **44a** is formed to be rectangular in a large sense, a rounded curved portion **45** is provided at a corner portion thereof. Thereby, a corner portion of each of the convex portions **41a** to **44a** is formed to be smoothly curved, which reduces the flow path resistance of the working fluid **2** in liquid form. Additionally, such an example is shown that two curved portions **45** are respectively provided at right and left ends in FIG. **19** of the convex portions **41a** to **44a**, and a linear portion **46** is provided between the two curved portions **45**. Consequently, the width $w3'$ of the first to fourth communicating grooves **51** to **54** is the distance between the linear portions **46** adjacent to each other in the first direction X of the convex portions **41a** to **44a**. The same is applied to a case where no curved portion **45** is provided at each of the convex portions **41a** to **44a** as shown in FIG. **6**. However, the shape of end portions of the convex portions **41a** to **44a** is not limited to this. For example, instead of providing the linear portion **46** at the right and left ends

respectively, the entire end portion may be curved (for example, semicircular.) In such a case, the width $w3'$ of each of the communicating grooves **51** to **54** is the smallest distance between the convex portions **41a** to **44a** adjacent to each other in the first direction X. Additionally, for clarity of the drawings, in FIG. **19**, the curved portions **45** and the linear portions **46** are shown in the fourth convex portions **44a** positioned at the bottom as a representative.

[0210] As shown in FIGS. **20** and **21**, in this embodiment, the width $w3'$ of the first to fourth communicating grooves **51** to **54** is larger than the depth $h1$ of the first to fourth main flow grooves **31** to **34** (more specifically, the depth of the first to fourth main flow groove body portions **31a** to **34a** which will be described later.) Here, when the shape of the transverse section of each of the main flow grooves **31** to **34** and the shape of the transverse section of each of the communicating grooves **51** to **54** are formed to be curved as described above, the depth of the grooves **31** to **34** and the depth of the communicating grooves **51** to **54** are the depth at a deepest position in the corresponding groove. The depth $h3'$ of the first to fourth communicating grooves **51** to **54** may be, for example, 10 μm to 250 μm .

[0211] In this embodiment, as shown in FIG. **22**, a depth $h1'$ of the first intersection **P1** and the second intersection **P2** of the first to fourth main flow grooves **31** to **34** is deeper than the depth $h1$ of a portion of the main flow grooves **31** to **34** excluding the first intersection **P1** and the second intersection **P2**. In other words, the first to fourth main flow grooves **31** to **34** further include the first to fourth main flow groove body portions **31a** to **34a** provided between the first intersection **P1** and the second intersection **P2**. Each of the first to fourth main flow groove body portions **31a** to **34a** is a portion positioned between the convex portions **41a** to **44a** adjacent to each other, and a portion positioned between the first intersection **P1** and the second intersection **P2** adjacent to each other. The depth $h1'$ of the first intersection **P1** and the second intersection **P2** is deeper than the depth $h1$ of the first to fourth main flow groove body portions **31a** to **34a**. The depth $h1'$ of the first intersection **P1** is a depth at a deepest position in the first intersection **P1**, and the depth $h1'$ of the second intersection **P2** is a depth at a deepest position in the second intersection **P2**.

[0212] More specifically, as shown in FIGS. **19** and **22**, the depth $h1'$ of the first intersection **P1** and the second intersection **P2** of the first main flow groove **31** is deeper than the depth $h1$ of a portion between the fourth convex portion **44a** and the first convex portion **41a** of the first main flow groove **31** (the first main flow groove body portion **31a**.) In the same manner, the depth $h1'$ of the first intersection **P1** and the second intersection **P2** of the second main flow groove **32** is deeper than the depth $h1$ of a portion between the first convex portion **41a** and the second convex portion **42a** of the second main flow groove **32** (the second main flow groove body portion **32a**.) The depth $h1'$ of the first intersection **P1** and the second intersection **P2** of the third main flow groove **33** is deeper than the depth $h1$ of a portion between the second convex portion **42a** and the third convex portion **43a** of the third main flow groove **33** (the third main flow groove body portion **33a**.) The depth $h1'$ of the first intersection **P1** and the second intersection **P2** of the fourth main flow groove **34** is deeper than the depth $h1$ of a portion between the third convex portion **43a** and the fourth convex portion **44a** of the fourth main flow groove **34** (the fourth main flow groove body portion **34a**.)

[0213] Also, the depth $h1'$ of the first intersection **P1** and the second intersection **P2** of the first to fourth main flow grooves **31** to **34** may be deeper than the depth $h3'$ of the first to fourth communicating grooves **51** to **54**. The depth $h1'$ of such first intersection **P1** and second intersection **P2** may be, for example, 20 μm to 300 μm .

[0214] Also, while the first to fourth convex portions **41a** to **44a** are formed to be rectangular in a large sense as shown in FIG. **19**, this shape is different from a planar shape of the first to fourth convex portions **41a** to **44a** as shown in FIG. **6**. In other words, the first to fourth convex portions **41a** to **44a** include a pair of first to fourth convex end portions **41b** to **44b** provided at both ends in the first direction X and first to fourth convex intermediate portions **41c** to **44c** provided between the pair of first to fourth convex end portions **41b** to **44b**. Among these, a width $w4$ of the first to

fourth convex intermediate portions **41c** to **44c** is smaller than the width **w2** of the first to fourth convex end portions **41b** to **44b** (corresponding to the width **w2** of the first to fourth convex portions **41a** to **44a** described above.)

[0215] More specifically, the width **w4** of the first convex intermediate portion **41c** is smaller than the width **w2** of the first convex end portion **41b**, and walls of the first convex portion **41a** (that is, the side wall **36** of the first main flow groove **31** and the side wall **35** of the second main flow groove **32**) are smoothly curved to be recessed toward an inner portion of the first convex portion **41a**. Consequently, the width **w4** of the first convex intermediate portion **41c** is the smallest distance between two walls. In the same manner, the width **w4** of the second convex intermediate portion **42c** is smaller than the width **w2** of the second convex end portion **42b**, and walls of the second convex portion **42a** (that is, the side wall **36** of the second main flow groove **32** and the side wall **35** of the third main flow groove **33**) are smoothly curved to be recessed toward an inner portion of the second convex portion **42a**. The width **w4** of the third convex intermediate portion **43c** is smaller than the width **w2** of the third convex end portion **43b**, and walls of the third convex portion **43a** (that is, the side wall **36** of the third main flow groove **33** and the side wall **35** of the fourth main flow groove **34**) are smoothly curved to be recessed toward an inner portion of the third convex portion **43a**. The width **w4** of the fourth convex intermediate portion **44c** is smaller than the width **w2** of the fourth convex end portion **44b**, and walls of the fourth convex portion **44a** (that is, the side wall **36** of the fourth main flow groove **34** and the side wall **35** of the first main flow groove **31**) are smoothly curved to be recessed toward an inner portion of the fourth convex portion **44a**. The width **w4** of such first to fourth convex intermediate portions **41c** to **44c** may be, for example, 15 μm to 175 μm .

[0216] As described above, the depth **h3'** of the first to fourth communicating grooves **51** to **54** is deeper than the depth **h1** of the first to fourth main flow groove body portions **31a** to **34a** of the first to fourth main flow grooves **31** to **34**, and the depth **h1'** of the first intersection **P1** and the second intersection **P2** of the first to fourth main flow grooves **31** to **34** is deeper than the depth **h1** of the first to fourth main flow groove body portions **31a** to **34a**. Thereby, a buffer region **Q** which is deeper than the depth **h1** of the first to fourth main flow groove body portions **31a** to **34a** is formed at a region from the second intersection **P2** through each of the first to fourth communicating grooves **51** to **54** to the first intersection **P1**. The working fluid **2** in liquid form can be stored in the buffer region **Q**.

[0217] More specifically, for example, the buffer region **Q** which is deeper than the depth **h1** of the first main flow groove body portion **31a** and the second main flow groove body portion **32a** is formed at a region from the second intersection **P2** of the first main flow groove **31** through the first communicating groove **51** to the first intersection **P1** of the second main flow groove **32**. Typically, each of the main flow grooves **31** to **34** and each of the communicating grooves **51** to **54** of the liquid flow path portion **30** is filled with the working fluid **2** in liquid form. Accordingly, since the depth of the buffer region **Q** (**h1'** and **h3'**) is deeper than the depth **h1** of the first to fourth main flow groove body portions **31a** to **34a**, a large quantity of working fluid **2** can be stored in the buffer region **Q**. As described above, since each of the main flow grooves **31** to **34** and each of the communicating grooves **51** to **54** are filled with the working fluid **2**, the working fluid **2** can be stored in the buffer region **Q** regardless of the attitude of the vapor chamber **1**.

[0218] In the same manner, the buffer region **Q** which is deeper than the depth **h1** of the second main flow groove body portion **32a** and the third main flow groove body portion **33a** is formed at a region from the second intersection **P2** of the second main flow groove **32** through the second communicating groove **52** to the first intersection **P1** of the third main flow groove **33**. The buffer region **Q** which is deeper than the depth **h1** of the third main flow groove body portion **33a** and the fourth main flow groove body portion **34a** is formed at a region from the second intersection **P2** of the third main flow groove **33** through the third communicating groove **53** to the first intersection **P1** of the fourth main flow groove **34**. The buffer region **Q** which is deeper than the depth **h1** of the

fourth main flow groove body portion **34a** and the first main flow groove body portion **31a** is formed at a region from the second intersection **P2** of the fourth main flow groove **34** through the fourth communicating groove **54** to the first intersection **P1** of the first main flow groove **31**. [0219] Additionally, while a large number of first intersections **P1** and a large number of second intersections **P2** are formed in each liquid flow path portion **30** of the vapor chamber **1**, as long as the depth **h1'** of at least one of the intersections **P1**, **P2** is deeper than the depth **h1** of the main flow groove body portions **31a** to **34a** (or the depth **h3'** of the communicating grooves **51** to **54**), retaining property of the working fluid **2** at the intersections **P1**, **P2** can be improved. Since this retaining property improves as the number of intersections **P1**, **P2** having **h1'** which is deeper than the depth **h1** of the main flow groove body portions **31a** to **34a** increases, the depth **h1'** of all the intersections **P1**, **P2** is preferably the same depth. However, the retaining property of the working fluid **2** can be evidently improved even when the depth **h1'** of a part of the intersections **P1**, **P2** is not deeper than the depth **h1** of the main flow groove body portions **31a** to **34a** due to a production error etc. The same is applied to the depth **h3'** of the communicating grooves **51** to **54**.

[0220] Here, a method of confirming the width and the depth of the main flow grooves **31** to **34** and the width and the depth of the communicating grooves **51** to **54** from the vapor chamber **1** in the finished form will be explained. Generally, the main flow grooves **31** to **34** and the communicating grooves **51** to **54** cannot be seen from the outside of the vapor chamber **1**. Consequently, such a method can be listed in which the width and the depth of the main flow grooves **31** to **34** and the communicating grooves **51** to **54** are confirmed from a cross-sectional shape obtained by cutting the vapor chamber **1** in the finished form at a desired position.

[0221] More specifically, firstly, the vapor chamber **1** is cut by a wire saw into a 10 mm square piece as a sample. After that, the sample is embedded in resin with vacuum degassing such that resin enters the vapor flow path recesses **12**, **21** and the liquid flow path portion **30** (the main flow grooves **31** to **34** and the communicating grooves **51** to **54**.) Next, trimming process is performed by a diamond knife to obtain a desired cross section. At this time, for example, using a diamond knife of a microtome (an ultra microtome manufactured by Leica microsystems GmbH etc.), trimming process is executed to a portion away from a measured object position by 40 μm . For example, assuming that a pitch of the communicating grooves **51** to **54** is 200 μm , by shaving the communicating grooves **51** to **54** adjacent to the communicating grooves **51** to **54** as a measured object by 160 μm , a portion which is 40 μm away from the communicating grooves **51** to **54** as the measured object can be specified. Next, a trimming-processed cutting surface is shaved to provide a cutting surface for observation. At this time, using a cross section sample manufacturing apparatus (for example, a cross section polisher manufactured by JEOL Ltd.), setting a protruding width of 40 μm , the voltage of 5 kV, and the time of 6 hours, the cutting surface is shaved in ion beam processing. Thereafter, the obtained cutting surface of the sample is observed. At this time, using a scanning electron microscope (for example, a scanning electron microscope manufactured by Carl Zeiss Co., Ltd.), setting the voltage of 5 kV, an operation distance of 3 nm and an observation magnification of 200 to 500 times, the cutting surface is observed. In this way, the width and the depth of the main flow grooves **31** to **34** and the communicating grooves **51** to **54** can be measured. Additionally, an observation magnification standard at the time of shooting is polaroid **545**. Also, the above-described method is one example, and an apparatus to be used or the measuring condition etc. can be arbitrarily determined in accordance with the shape and the configuration etc. of the sample.

[0222] Incidentally, as described above, the width **w3'** of the first to fourth communicating grooves **51** to **54** is larger than the width **w1** of the first to fourth main flow grooves **31** to **34**. Thereby, the buffer region **Q** is a region which opens wider than the first to fourth main flow groove body portions **31a** to **34a**. Consequently, in the second half etching step as shown in FIG. **10**, more etching liquid enters the buffer region **Q** than the first to fourth main flow groove body portions **31a** to **34a**. As a result, erosion by the etching liquid progresses in the buffer region **Q**, and the

depth of the buffer region Q is made deeper. Moreover, in the buffer region Q, a portion corresponding to the first intersection P1 and the second intersection P2 communicates with the first to fourth main flow groove body portions 31a to 34a, so that the etching liquid easily enters this portion than the first to fourth communicating grooves 51 to 54. Thereby, the depth h1' of the first intersection P1 and the second intersection P2 can be deeper than the depth h3' of the first to fourth communicating grooves 51 to 54. In this way, the buffer region Q as shown in FIG. 22 is formed.

[0223] Also, because more etching liquid enters the buffer region Q, erosion by the etching liquid progresses at a portion facing the first intersection P1 and the second intersection P2 in walls of the first to fourth convex portions 41a to 44a (the side walls 35, 36 of the first to fourth main flow grooves 31 to 34.) Thereby, the walls of the first to fourth convex portions 41a to 44a are eroded like boring by the etching liquid to produce a smoothly curved shape to be recessed toward the inner portion of each of the convex portions 41a to 44a.

[0224] Additionally, in the second half etching step as shown in FIG. 10, as described above, the second resist film is formed to have a pattern on the upper surface 13a of each lower flow path wall portion 13, and the etching liquid enters the resist opening of the second resist film to form the first to fourth main flow grooves 31 to 34 and the first to fourth communicating grooves 51 to 54. Even in a case where this resist opening is formed to be parallel with the first direction X and the second direction Y, since the width w3' of the first to fourth communicating grooves 51 to 54 is larger than the width w1 of the first to fourth main flow grooves 31 to 34, the etching liquid easily enters the buffer region Q. As a result, the above-described buffer region Q can be formed.

[0225] In the vapor chamber 1 according to this embodiment, the vapor of the working fluid 2 diffused to the peripheral portion of the vapor chamber 1 is cooled to be condensed. The working fluid 2 condensed in liquid form enters the main flow groove 31 through the first to fourth communicating grooves 51 to 54. Here, as described above, since the width w3' of the first to fourth communicating grooves 51 to 54 is larger than the width w1 of the first to fourth main flow grooves 31 to 34, the flow path resistance of the working fluid 2 in each of the communicating grooves 51 to 54 is reduced. Consequently, the working fluid 2 in liquid form attached to the wall surfaces of each of the vapor flow path recesses 12, 21 passes through each of the communicating grooves 51 to 54 to smoothly enter each of the main flow grooves 31 to 34. In addition, each of the main flow grooves 31 to 34 and each of the communicating grooves 51 to 54 are filled with the working fluid 2 in liquid form.

[0226] When the working fluid 2 filled in each of the main flow grooves 31 to 34 is transported toward the evaporating portion 11, a part of the working fluid 2 is directed to the evaporating portion 11 passing through the first intersection P1 and the second intersection P2. In the first intersection P1 and the second intersection P2, the working fluid 2 obtains the thrust toward the evaporating portion 11 mainly from capillary action by the corner portions 37 formed by the side walls 35, 36 of the first to fourth main flow grooves 31 to 34 and the lower surface 22a of each upper flow path wall portion 22.

[0227] On the other hand, a part of the working fluid 2 toward the evaporating portion 11 is drawn into the buffer region Q constituted by the first intersection P1 or the second intersection P2 to be stored.

[0228] Here, when dryout occurs in the first to fourth main flow groove body portions 31a to 34a, the working fluid 2 stored in the buffer region Q moves toward an occurrence portion of the dryout. More specifically, for example, when the dryout occurs at the first main flow groove body portion 31a, the working fluid 2 moves to an occurrence portion of the dryout by capillary action of the first main flow groove body portion 31a from the buffer region Q which is closest to the occurrence portion of the dryout. Thereby, the occurrence portion of the dryout is filled with the working fluid 2 to eliminate the dryout.

[0229] Also, in the first to fourth main flow groove body portions 31a to 34a, when air bubbles are

generated in the working fluid 2 in liquid form due to its vapor, the air bubbles are drawn into the buffer region Q at a downstream side (on a side of the evaporating portion 11) to be retained. Since the depth of the buffer regions Q is deeper than the depth h1 of the first to fourth main flow groove body portions 31a to 34a, the air bubbles drawn into the buffer region Q is inhibited from moving from the buffer region Q to the main flow groove body portions 31a to 34a. Consequently, the air bubbles generated in the main flow groove body portions 31a to 34a can be captured by the buffer region Q, which inhibits the flow of the working fluid 2 to the evaporating portion 11 from being blocked due to the air bubbles.

[0230] In this way, according to this embodiment, the width w3' of the first to fourth communicating grooves 51 to 54 is larger than the width w1 of the first to fourth main flow grooves 31 to 34. This reduces the flow path resistance of the working fluid 2 in each of the communicating grooves 51 to 54. As a result, the working fluid 2 in liquid form condensed from the vapor is allowed to smoothly enter each of the main flow grooves 31 to 34. In other words, the working fluid 2 can smoothly enter not only the main flow grooves 31 to 34 at a closer side to the vapor flow path recesses 12, 21, but also the main flow grooves 31 to 34 at a farther side from the vapor flow path recesses 12, 21, which improves the transport function of the working fluid 2 condensed in liquid form. As a result, the transport function of the working fluid 2 in liquid form can be improved, and thermal transport efficiency can be improved.

[0231] Also, according to this embodiment, the depth h3' of the first to fourth communicating grooves 51 to 54 is deeper than the depth h1 of the first to fourth main flow grooves 31 to 34. Thereby, the buffer region Q which stores the working fluid 2 can be formed at each of the communicating grooves 51 to 54. Consequently, when the dryout occurs at the main flow grooves 31 to 34, the working fluid 2 stored in the buffer region Q can be moved to the occurrence portion of the dryout. This eliminates the dryout, which recovers the transport function of the working fluid 2 in each of the main flow grooves 31 to 34. Also, when air bubbles are generated in the main flow grooves 31 to 34, the air bubbles can be drawn into the buffer region Q to be captured. Also from this point, the transport function of the working fluid 2 in each of the main flow grooves 31 to 34 can be recovered.

[0232] Also, according to this embodiment, the depth h1' of the first intersection P1 and the second intersection P2 of the first to fourth main flow grooves 31 to 34 is deeper than the depth h1 of the first to fourth main flow groove body portions 31a to 34a. Thereby, the buffer region Q can extend to the first intersection P1 and the second intersection P2. Consequently, the storage volume of the working fluid 2 in the buffer region Q can be increased, and the dryout can be eliminated more easily.

[0233] Also, according to this embodiment, the depth h1' of the first intersection P1 and the second intersection P2 of the first to fourth main flow grooves 31 to 34 is deeper than the depth h3' of the first to fourth communicating grooves 51 to 54. Thereby, in the buffer region Q, the depth of the buffer region Q can be made deeper on a side close to the occurrence portion of the dryout. Consequently, the working fluid 2 stored can be smoothly moved to the occurrence portion of the dryout, which eliminates the dryout more easily.

[0234] Also, according to this embodiment, the width w4 of the first to fourth convex intermediate portions 41c to 44c of the first to fourth convex portions 41a to 44a is smaller than the width w2 of the first to fourth convex end portions 41b to 44b. Thereby, a plain area of the first intersection P1 and the second intersection P2 can be increased. Consequently, the storage volume of the working fluid 2 in the buffer region Q can be increased, which eliminates the dryout more easily.

[0235] Also, according to this embodiment, the rounded curved portion 45 is provided at corner portions of each of the convex portions 41a to 44a. Thereby, the corner portion of each of the convex portions 41a to 44a can be formed to be smoothly curved, which eliminates the flow path resistance of the working fluid 2 in liquid form.

Third Embodiment

[0236] Next, a vapor chamber, a metallic sheet for the vapor chamber and a manufacturing method of the vapor chamber according to a third embodiment of the present invention will be explained using FIGS. 23 to 25.

[0237] In the third embodiment shown in FIGS. 23 to 25, a main difference is that a main flow groove convex portion protrudes in the first to fourth main flow grooves, and a communicating groove convex portion protrudes in the first to fourth communicating grooves, and the other configurations are substantially the same as in the second embodiment as shown in FIGS. 19 to 22. Additionally, in FIGS. 23 to 25, the same components as those in the second embodiment as shown in FIGS. 19 to 22 are applied the same reference numerals, and a detailed explanation thereof is omitted.

[0238] As shown in FIG. 23, in this embodiment, the upper metallic sheet 20 includes a plurality of main flow groove convex portions 27 provided in the lower surface 20a. Each of the main flow groove convex portions 27 protrudes to the corresponding one of the main flow grooves 31 to 34 of the lower metallic sheet 10 from the lower surface 20a. A lower end of each main flow groove convex portion 27 is separated from a bottom portion of the main flow grooves 31 to 34, so that the flow path of the working fluid 2 is secured. Also, each main flow groove convex portion 27 is formed to extend in the first direction X along the corresponding one of the main flow grooves 31 to 34.

[0239] A cross section of each main flow groove convex portion 27 is formed to be curved. Also, a lateral edge of each main flow groove convex portion 27 contacts or is close to the side walls 35, 36 of the first to fourth main flow grooves 31 to 34. Thereby, the corner portions 37 formed by the side walls 35, 36 of the first to fourth main flow grooves 31 to 34 and the lower surface 22a of each upper flow path wall portion 22 are formed to be wedge-shaped (or like an acute angle.) In this way, a cross section of a flow path defined by the main flow grooves 31 to 34 and the main flow groove convex portions 27 (a cross section of a flow path in the second direction Y) is formed in a crescent shape as shown in FIG. 23.

[0240] Also, as shown in FIGS. 24 and 25, in this embodiment, the upper metallic sheet 20 includes a plurality of communicating groove convex portions 28 provided in the lower surface 20a. Each communicating groove convex portion 28 protrudes to the corresponding one of the communicating groove 51 to 54 of the lower metallic sheet 10 from the lower surface 20a. A lower end of each communicating groove convex portion 28 is separated from a bottom portion of the communicating grooves 51 to 54, so that the flow path of the working fluid 2 is secured. Also, each communicating groove convex portion 28 is formed to extend in the second direction Y along the corresponding one of the communicating grooves 51 to 54. At the first intersections P1 and the second intersections P2 of the first to fourth main flow grooves 31 to 34, the main flow groove convex portions 27 and the communicating groove convex portions 28 described above intersect to form a T shape.

[0241] A cross section of each communicating groove convex portion 28 is formed to be curved in the same manner as each main flow groove convex portion 27. Also, a lateral edge of each communicating groove convex portion 28 contacts or is close to the pair of side walls 55, 56 (see FIG. 19) extending in the second direction Y of the first to fourth communicating grooves 51 to 54. Thereby, the corner portions 57 formed by the side walls 55, 56 of the first to fourth communicating grooves 51 to 54 and the lower surface 22a of each upper flow path wall portion 22 is formed to be wedge-shaped (or like an acute angle.) In this way, a cross section of a flow path defined by the communicating grooves 51 to 54 and the communicating groove convex portions 28 (a cross section of a flow path in the first direction X) is formed in a crescent shape as shown in FIG. 24. Also, the cross section of the flow path in the second direction Y is formed in an elongated crescent shape as shown in FIG. 25, because it is formed such that the cross section of the flow path in the second direction Y of the first to fourth communicating grooves 51 to 54 is interposed between the cross section of the flow path of the main flow grooves 31 to 34 as shown in FIG. 23.

Additionally, in FIG. 19, for clarity of the drawings, the reference numerals 55, 56 are applied to the side walls only in the third communicating groove 53. The side walls 55, 56 correspond to the above-described linear portion 46 of the convex portions 41a to 44a.

[0242] The main flow groove convex portions 27 and the communicating groove convex portions 28 are formed, for example, by half etching of the upper metallic sheet 20 to form the upper flow path wall portions 22 etc., and then press working of the upper metallic sheet 20 alone.

Alternatively, in the permanent joint step as shown in FIG. 12, a welding pressure to be applied to the lower metallic sheet 10 and the upper metallic sheet 20 is increased to form the main flow groove convex portions 27 and the communicating groove convex portions 28. In other words, by increasing the welding pressure, a part of each upper flow path wall portion 22 of the upper metallic sheet 20 can be inserted into the first to fourth main flow grooves 31 to 34 and the first to fourth communicating grooves 51 to 54. As a result, the main flow groove convex portions 27 and the communicating groove convex portions 28, having a curved cross section, can be formed.

[0243] In this way, according to this embodiment, each main flow groove convex portion 27 protrudes to the corresponding one of the main flow grooves 31 to 34 of the lower metallic sheet 10 from the lower surface 20a of the upper metallic sheet 20. Thereby, the corner portions 37 formed by the side walls 35, 36 of the first to fourth main flow grooves 31 to 34 and the lower surface 22a of each upper flow path wall portion 22 can be formed as a minute space defined by the side walls 35, 36 of the first to fourth main flow grooves 31 to 34 and the main flow groove convex portions 27. This improves capillary action at the corner portions 37. As a result, the transport function of the working fluid 2 in liquid form in each of the main flow grooves 31 to 34 can be improved, so that thermal transport efficiency can be improved. In particular, even when the first intersection P1 and the second intersection P2 of each of the main flow grooves 31 to 34 are configured as the buffer region Q as shown in FIG. 19, a high thrust toward the evaporating portion 11 can be applied to the working fluid 2 at the first intersection P1 and the second intersection P2 due to capillary action by the main flow groove convex portions 27, which improves the transport function of the working fluid 2 effectively.

[0244] Also, according to this embodiment, a cross section of the main flow groove convex portions 27 is formed to be curved. Thereby, the corner portions 37 can have a shape like an end of the crescent shape. Consequently, capillary action at the corner portions 37 can be further improved.

[0245] Also, according to this embodiment, each communicating groove convex portion 28 protrudes to the corresponding one of the communicating grooves 51 to 54 of the lower metallic sheet 10 from the lower surface 20a of the upper metallic sheet 20. Thereby, the corner portions 57 formed by the side walls 55, 56 of the first to fourth communicating grooves 51 to 54 and the lower surface 22a of each upper flow path wall portion 22 can be formed as a minute space defined by the side walls 55, 56 of the first to fourth communicating grooves 51 to 54 and the communicating groove convex portions 28. This improves capillary action at the corner portions 57.

[0246] Here, the working fluid 2 in liquid form condensed from the vapor passes through the first to fourth communicating grooves 51 to 54 to enter the first to fourth main flow grooves 31 to 34 as described above. Consequently, since capillary action of the first to fourth communicating grooves 51 to 54 is improved, the working fluid 2 condensed in liquid form is allowed to smoothly enter the first to fourth main flow grooves 31 to 34. Due to capillary action of the first to fourth communicating grooves 51 to 54, the working fluid 2 condensed in liquid form can smoothly enter not only the first to fourth main flow grooves 31 to 34 at a closer side to the vapor flow path recesses 12, 21, but also the first to fourth main flow grooves 31 to 34 at a farther side from the vapor flow path recesses 12, 21, which improves the transport function of the working fluid 2 condensed in liquid form. Also, since the width w3' of the first to fourth communicating grooves 51 to 54 is larger than the width w1 of the first to fourth main flow grooves 31 to 34, the flow path resistance of the working fluid 2 in the first to fourth communicating grooves 51 to 54 can be

reduced, and also in this point, the working fluid 2 condensed in liquid form is allowed to smoothly enter each of the first to fourth main flow grooves 31 to 34. Moreover, the working fluid 2 entering the first to fourth main flow grooves 31 to 34 can be smoothly transported to the evaporating portion 11 due to capillary action of the first to fourth main flow grooves 31 to 34. As a result, as the entire liquid flow path portion 30, the transport function of the working fluid 2 in liquid form can be improved. Also, as described above, since capillary action of the first to fourth communicating grooves 51 to 54 is improved, when the dryout occurs, the working fluid 2 can reciprocate among the first to fourth main flow grooves 31 to 34 due to the capillary action of the first to fourth communicating grooves 51 to 54, so that the dryout can be eliminated.

[0247] Also, according to this embodiment, a cross section of the communicating groove convex portions 28 is formed to be curved. Thereby, the corner portions 57 can have a shape like an end of the crescent shape. Consequently, capillary action at the corner portions 57 can be further improved.

[0248] Additionally, in this embodiment described above, an example in which the cross section of the first to fourth main flow grooves 31 to 34 and the cross section of the first to fourth communicating grooves 51 to 54 are formed to be curved has been explained. However, not limited to this, the cross section of the first to fourth main flow grooves 31 to 34 and the cross section of the first to fourth communicating grooves 51 to 54 may be formed to be rectangular as shown in FIG. 7. Also in this case, capillary action in the corner portions 37, 57 can be improved, so that the transport function of the working fluid 2 in liquid form in the first to fourth main flow grooves 31 to 34 and the first to fourth communicating grooves 51 to 54 can be improved. To make the cross section rectangular, the main flow grooves 31 to 34 and the communicating grooves 51 to 54 are preferably formed by press working or cutting work.

[0249] Also, in this embodiment described above, an example in which the width $w3'$ of the first to fourth communicating grooves 51 to 54 is larger than the width $w1$ of the first to fourth main flow grooves 31 to 34 has been explained. However, not limited to this, as shown in FIG. 6, the width $w3'$ of each of the communicating grooves 51 to 54 is not necessarily larger than the width $w1$ of each of the main flow grooves 31 to 34. In other words, an effect of improving the transport function of the working fluid 2 in liquid form in the main flow grooves 31 to 34 with improvement of capillary action of the first to fourth main flow grooves 31 to 34 by the main flow groove convex portions 27 can be exerted regardless of the magnitude relationship between the width $w3'$ of the communicating grooves 51 to 54 and the width $w1$ of the main flow grooves 31 to 34. In the same manner, an effect of improving the transport function of the working fluid 2 condensed in liquid form with improvement of capillary action of the first to fourth communicating grooves 51 to 54 by the communicating groove convex portions 28 can be exerted regardless of the magnitude relationship between the width $w3'$ of the communicating grooves 51 to 54 and the width $w1$ of the main flow grooves 31 to 34.

[0250] The present invention is not directly limited to the above embodiments and modifications, and in an implementation phase, can be embodied with modification of constituent elements without departing the gist of the present invention. Also, various inventions can be made by an appropriate combination of a plurality of constituent elements disclosed in the above embodiments and modifications. Several constituent elements may be deleted from all the constituent elements shown in the embodiments and modifications. Moreover, in each of the above embodiments and modifications, the configuration of the lower metallic sheet 10 may be replaced with the configuration of the upper metallic sheet 20.

Claims

1-15. (canceled)

16. A vapor chamber in which a working fluid is enclosed, the vapor chamber comprising: a first

metallic sheet; a second metallic sheet on the first metallic sheet; a vapor flow path portion through which a vapor of the working fluid passes; and a liquid flow path portion through which the working fluid in liquid form passes, wherein the liquid flow path portion is in a surface of the first metallic sheet on a side of the second metallic sheet, the liquid flow path portion includes a first main flow groove and a second main flow groove each of which extends in a first direction and through which the working fluid in liquid form pass, a first communicating groove extending in a second direction intersecting the first direction in a planar view and communicating the first main flow groove and the second main flow groove, and a first convex array adjacent to the first main flow groove and adjacent to the second main flow groove, the first convex array including a plurality of first convex portions arranged in the first direction and separated via the first communicating groove, the second metallic sheet includes an abutting surface which abuts a surface of the first metallic sheet on a side of the second metallic sheet and covers the second main flow groove, and the entirety of at least one first convex portion of the first convex portions abuts the abutting surface.

17. The vapor chamber according to claim 16, wherein the liquid flow path portion includes a second communicating groove extending in the second direction and communicating the second main flow groove and a second convex array arranged on an opposite side from the first convex array with respect to the second main flow groove, the second convex array including a plurality of second convex portions arranged in the first direction and separated via the second communicating groove, and at least one of the second convex portion of the second convex portions abuts the abutting surface.

18. The vapor chamber according to claim 16, wherein the liquid flow path portion includes a second communicating groove extending in the second direction and communicating the second main flow groove and a second convex array arranged on an opposite side from the first convex array with respect to the second main flow groove, the second convex array including a plurality of second convex portions arranged in the first direction and separated via the second communicating groove, the second main flow groove includes a first intersection at which the first communicating groove faces the second convex portion and a second intersection at which the second communicating groove faces the first convex portion, and the first intersection and the second intersection of the second main flow groove are adjacent to each other.

19. The vapor chamber according to claim 16, wherein the liquid flow path portion includes a second communicating groove extending in the second direction and communicating the second main flow groove and a second convex array arranged on an opposite side from the first convex array with respect to the second main flow groove, the second convex array including a plurality of second convex portions arranged in the first direction and separated via the second communicating groove, the second main flow groove includes a first intersection at which the first communicating groove faces the second convex portion and a second intersection at which the second communicating groove faces the first convex portion, and the first intersection and the second intersection of the second main flow groove are alternately arranged in the first direction.

20. The vapor chamber according to claim 16, wherein the liquid flow path portion includes a second communicating groove extending in the second direction and communicating the second main flow groove and a second convex array arranged on an opposite side from the first convex array with respect to the second main flow groove, the second convex array including a plurality of second convex portions arranged in the first direction and separated via the second communicating groove, and a width of the second main flow groove is larger than a width of the first convex portions and a width of the second convex portions.

21. The vapor chamber according to claim 16, wherein the liquid flow path portion includes a second convex array arranged on an opposite side from the first convex array with respect to the second main flow groove, the second convex array including a plurality of second convex portions arranged in the first direction and separated via the second communicating groove, and a width of

the second main flow groove is smaller than a width of the first convex portions and a width of the second convex portions.

22. The vapor chamber according to claim 16, wherein a rounded curved portion is arranged at a corner portion of each first convex portion.

23. An electronic device comprising: a housing; a device housed in the housing; and a vapor chamber according to claim 16, wherein the vapor chamber is thermally contacted to the device.
